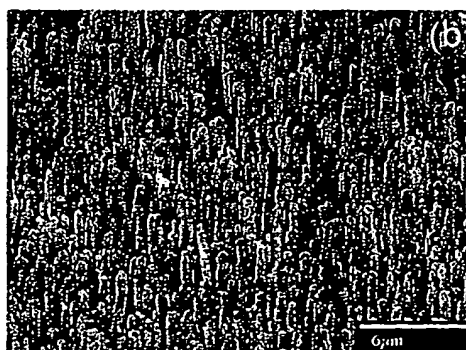
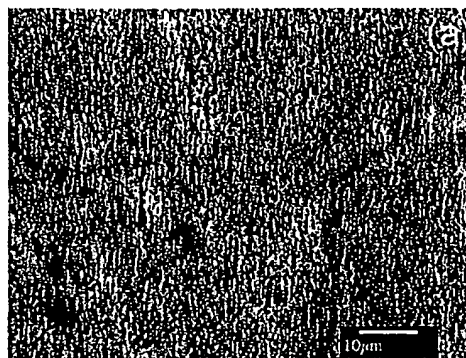




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<b>(21) International Application Number:</b> PCT/US99/13648  <b>(22) International Filing Date:</b> 18 June 1999 (18.06.99)  <b>(30) Priority Data:</b> 60/089,965 19 June 1998 (19.06.98) US 60/099,708 10 September 1998 (10.09.98) US  <b>(71) Applicant:</b> THE RESEARCH FOUNDATION OF STATE UNIVERSITY OF NEW YORK [US/US]; Suite 200 UB Commons, Amherst, NY 14228-2567 (US).  <b>(72) Inventors:</b> REN, Zhifeng; 56 Honeysuckle Way, East Amherst, NY 14051 (US). HUANG, Zhongping; 114 Kenville Road, Cheektowaga, NY 14228 (US). WANG, Jui, H.; 477 LeBrun Road, Amherst, NY 14226 (US). WANG, Dezhi; 1355 Millersport Highway #6, Williamsville, NY 14221 (US).  <b>(74) Agents:</b> ARNOLD, Jeffery, B. et al.; Nixon, Hargrave, Devans & Doyle LLP, Clinton Square, P.O. Box 1051, Rochester, NY 14603 (US).		<b>(81) Designated States:</b> CA, JP, KR, MX, European patent (AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE).  <b>Published</b> <i>With international search report.</i> <i>Before the expiration of the time limit for amending the</i> <i>claims and to be republished in the event of the receipt of</i> <i>amendments.</i>
<b>(54) Title:</b> FREE-STANDING AND ALIGNED CARBON NANOTUBES AND SYNTHESIS THEREOF  <b>(57) Abstract</b>  One or more highly-oriented, multi-walled carbon nanotubes are grown on an outer surface of a substrate initially disposed with a catalyst film or catalyst nano-dot by plasma enhanced hot filament chemical vapor deposition of a carbon source gas and a catalyst gas at temperatures between 300 °C and 3000 °C. The carbon nanotubes range from 4 to 500 nm in diameter and 0.1 to 50 µm in length depending on growth conditions. Carbon nanotube density can exceed to 10 <sup>4</sup> nanotubes/mm <sup>2</sup> . Acetylene is used as the carbon source gas, and ammonia is used as the catalyst gas. Plasma intensity, carbon source gas to catalyst gas ratio and their flow rates, catalyst film thickness, and temperature of chemical vapor deposition affect the lengths, diameters, density, and uniformity of the carbon nanotubes. The carbon nanotubes of the present invention are useful in electrochemical applications as well as in electron emission, structural composite, material storage, and microelectrode applications.		



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## **FREE-STANDING AND ALIGNED CARBON NANOTUBES AND SYNTHESIS THEREOF**

This application claims the benefit of U.S. Provisional Patent Application Serial No. 60/089,965, filed June 19, 1998, and U.S. Provisional Patent Application Serial  
5 No. 60/099,708, filed September 10, 1998.

This invention was made through the support of the U.S. Army Research Office (Grant No. DAAG55-97-1-0139). The Federal Government may retain certain rights in the invention.

### **FIELD OF THE INVENTION**

10 The present invention relates to a product with a substrate having one or more carbon nanotubes, a method of producing that product, and devices utilizing the product.

### **BACKGROUND OF THE INVENTION**

Since the first observation of carbon nanotubes, numerous papers have  
15 reported studies on the yield of well-graphitized nanotubes, their diameter and wall thickness (single or multiple), growth mechanisms, alignment, electron emission properties, nanodevices, theoretical predictions, and potential applications. Selective positioning and growth of carbon nanotubes is necessary for future integration with conventional microelectronics as well as the development of novel devices. However,  
20 limited progress has been reported in the controlled placement of nanotubes. Alignment of the carbon nanotubes is particularly important to enable both fundamental studies and applications, such as cold-cathode flat panel displays, chargeable batteries, and vacuum microelectronics.

Specifically, vertical alignment has been an important goal due to its  
25 technological importance for applications such as scanning probe microscopy and field emission flat panel displays. Attempts to manipulate nanotubes for these applications have been made by post-growth methods such as cutting a polymer resin-nanotube composite, or drawing a nanotube-ethanol suspension through a ceramic filter. Because these techniques are difficult and labor intensive, *in situ* aligning of nanotubes during

growth using techniques such as the nanopores of porous alumina membranes and laser etched nanotracts have been attempted.

There has been little success in obtaining alignment of carbon nanotubes on large areas until the report by Li et al., "Large-Scale Synthesis of Aligned Carbon Nanotubes," Science, 274:1701-1703 (1996) ("Li"). Li discusses the growth of aligned carbon nanotubes on mesoporous silica containing iron nanoparticles via thermal decomposition of acetylene gas in nitrogen gas at temperatures above 700°C. In this method, the substrate is prepared by a sol-gel process from tetraethoxysilane hydrolysis in iron nitrate aqueous solution. The gel is then calcined 10 hours at 450°C at  $10^{-2}$  Torr. A silica network with relatively uniform pores is obtained with iron oxide nanoparticles embedded in the pores. The iron oxide nanoparticles are then reduced at 550°C in 180 Torr of flowing (9% H<sub>2</sub> / N<sub>2</sub> (110 cm<sup>3</sup> / min) for 5 hours to obtain iron nanoparticles. Thereafter, nanotubes are grown in a gas environment of a mixture of 9% acetylene in nitrogen at 700°C. Aligned nanotube growth is along the axial direction of the pores. Only the nanotubes which grow out of the vertical pores are aligned. Nanotubes which grow from the iron particles on the surface and in the dispersed, inclined pores are random and non-oriented. In this method, nanotube alignment is limited to the constraint of the vertically aligned pores. Further, the density and diameter of aligned carbon nanotubes is respectively limited in direct proportion to the amount and size of the iron nanoparticles and the diameter of the pores.

As disclosed in Li, a temperature of at least 700°C is required to decompose acetylene and induce carbon nanotube growth. Unfortunately, this high temperature requirement limits substrate selection. For example, a glass substrate is unsuited for use in this method due to its low strain point temperature. A glass produced by Corning Incorporated (Corning, New York) has the highest known flat panel display glass deformation or strain point temperature of 666°C. Typically, a commercially available flat panel display glass has a strain point temperature between 500°C and 590°C. At 700°C, glass substrates deform and inhibit aligned carbon nanotube growth. Accordingly, any substrate suitable for use with this method must have a melting point or strain point temperature above 700°C.

Terrones et al., "Controlled Production of Aligned-Nanotube Bundles," Nature, 388: 52-55 (1997) ("Terrones") disclose a method for laser induced growth of

nanotube bundles aligned on a substrate under high temperature conditions. A thin film of cobalt is deposited on a silica plate by laser ablation and thereafter etched with a single laser pulse to create linear nanotracks. 2-amino-4,6-dichloro-s-triazine is then disposed onto the silica plate in the presence of argon gas within a two stage oven. The first oven  
5 is heated to 1,000°C and then allowed to cool to room temperature. The second oven is heated to and maintained at 950°C. Although carbon nanotubes grow along the edges of the eroded nanotracks, growth only occurs on the substrate bottom surface and in a non-vertical fashion. Carbon nanotubes do not grow on a similarly prepared substrate top surface which indicates nanotube growth according to this method is gravity dependent.  
10 Again, for the reasons discussed above, substrate selection for this method is limited to a substrate having either a strain point or melting point temperature above 1,000°C. Further, nanotube density is directly limited to the number of nanotracks etched into the substrate surface.

Thus, there remains a need for a method of forming aligned, vertically or  
15 otherwise, carbon nanotubes at temperatures below 700°C. Similarly, there remains a need for a substrate which has carbon nanotubes vertically aligned on the substrate surface. Further, there remains a need for a method of forming individual, free-standing carbon nanotubes, and a substrate with one or more individual, free-standing carbon nanotubes disposed on the substrate surface. The present invention is directed to  
20 overcoming these deficiencies in the art.

### SUMMARY OF THE INVENTION

The present invention relates to a product which has a substrate and either  
(1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$   
nanotubes per square millimeter of substrate, (2) a plurality of substantially aligned  
25 carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate, (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about 300°C and 700°C, (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from the substrate outer surface. or (5) one or more free-standing carbon nanotubes originating and  
30 extending outwardly from the substrate outer surface.

Carbon nanotubes are synthesized by plasma-enhanced hot filament chemical vapor deposition of a carbon source gas in a reduced pressure environment in the presence of a catalyst gas at temperatures as low as between 300°C and 3000°C in a volume ratio range of carbon source gas to catalyst gas from 1:2 to 1:10. Growth of  
5 large arrays of well-aligned carbon nanotubes having a diameter between 4 to 500 nm occur on a substrate coated with a thin metal catalyst film. Free-standing carbon nanotubes are grown on metal catalyst nano-dots disposed on the substrate.

The present invention provides a method of forming aligned, vertically or otherwise, carbon nanotubes at temperatures below 700°C. Further, products made in  
10 accordance with this method provide a substrate which has carbon nanotubes vertically aligned on the substrate surface. Further, a product made in accordance with the method of the present invention includes a substrate having individual, free-standing carbon nanotubes. Still further, a product made in accordance with the method of the present invention includes a substrate having one or more individual, free-standing carbon  
15 nanotubes disposed on the substrate surface. Products of the present invention are useful in electrochemical applications as well as in electron emission, structural composite, material storage, and microelectrode applications.

### BRIEF DESCRIPTION OF THE DRAWINGS

20

Figures 1A-B are scanned images showing alignment of carbon nanotubes grown on a large-area of polycrystalline Ni substrates.

Figure 2 is a scanned image of a scanning electron microscope micrograph of showing carbon nanotubes grown at a higher plasma intensity under the conditions  
25 listed in Table 1(b).

Figure 3 is a scanned image showing carbon nanotubes with higher aspect ratios synthesized with a higher plasma intensity than that used for the carbon nanotubes shown in Figure 2.

Figure 4 is a scanned image showing a cluster of carbon nanotubes scraped  
30 off a Ni substrate directly onto a Cu TEM grid, with the insert showing a cross-section image from a portion of a single multi-walled carbon nanotube structure.

Figures 5A-B are scanned images showing carbon nanotubes aligned substantially perpendicular to a substrate over large areas growth conditions as listed in Table 2. Figure 5B is an enlarged view of Figure 5A along a peeled edge to show carbon nanotube diameters, length, straightness, and uniformity.

5                Figures 6A-C are scanned images showing scanning electron microscope surface morphology of the nickel catalyst layers. Figure 6A illustrates the effects of  $\text{NH}_3$  plasma etching for 3 minutes. Figure 6B illustrates the effects of  $\text{N}_2$  plasma etching for 3 minutes. Figure 6C shows an as-sputtered smooth catalyst surface.

10              Figures 7A-B are scanned images showing carbon nanotubes grown under the conditions listed in Table 2. Figure 7B is an enlarged view of Figure 7A to show carbon nanotube diameters and distributions.

15              Figure 8A is a scanned image showing thinner carbon nanotubes grown on thinner (15 nm) nickel-coated glass under the conditions listed in Table 2. Figure 8B is a scanned image showing carbon nanotube with approximately 20 nm diameters grown under the conditions listed in Table 2.

Figures 9A-B are scanned images showing the interior and wall structures of a typical thin carbon nanotubes, wherein Figure 9A is a cross-section view and Figure 9B is a plan view.

20              Figure 10 is a scanned image showing the large area growth of well-aligned carbon nanotubes on glass.

Figure 11 is a scanned image showing well-aligned carbon nanotubes on silicon.

Figure 12 is a scanned image showing very short carbon nanotubes grown on silicon for only 2 minutes.

25              Figure 13 is a scanned image showing open ended carbon nanotubes etched by  $\text{HNO}_3$  for 1 minute.

Figure 14 is a scanned image showing carbon nanotubes subjected to Ar ion sputtering.

Figure 15 is a scanned image showing a side view of well-aligned carbon nanotubes grown at an angle with respect to the substrate.

5                   Figure 16 is a scanned image showing a top view of the carbon nanotubes of Figure 15.

Figure 17A is a scanned image showing grown carbon nanotubes at the edge of a metal pad. Figure 17B is a scanned image showing a region similar to Figure 17A in which the carbon nanotubes are broken.

10                   Figures 18A-F are a series of scanned images displaying various viewing angles of carbon nanotube obelisks grown from a patterned array of catalyst nano-dots. Figure 18A is a perspective view of a plurality of patterned arrays. Figure 18B is a top view of the patterned arrays of Figure 18A at a reduced magnification. Figure 18C is a perspective view of one patterned array. Figure 18D is a top view of one patterned array.  
15   Figure 18E is a perspective view at an increased magnification of the patterned array of Figure 18C. Figure 18F is a perspective view of spaced-apart carbon nanotube obelisks.

Figure 19 is a scanned image showing an elevation view of a carbon nanotube obelisk.

20                   Figure 20 is a partial, top view of a field emission display apparatus of the present invention.

Figure 21 is a perspective view of a probe for a scanning electron microscope of the present invention.

Figure 22 is a schematic illustrating an example of a scanning electron microscope of the present invention.

25                   Figure 23 is a schematic drawing illustrating an example of the basic construction of a battery of the present invention.



Figure 24 is a schematic drawing illustrating a fuel cell of the present invention.

Figure 25 is a schematic drawing illustrating an electromagnetic interference shield disposed between an electromagnetic interference source and an electronic component.

Figure 26 is a schematic drawing illustrating a microelectrode of the present invention.

### DETAILED DESCRIPTION OF THE INVENTION

The present invention relates to a product which includes a substrate and one or more hollow core carbon nanotubes originating from a surface of the substrate. When the product has more than one carbon nanotube, the carbon nanotubes are well-aligned and may lie on or extend either perpendicularly or non-perpendicularly from the substrate surface. Embodiments of the product of the present invention include the substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate, (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate, (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about  $300^{\circ}\text{C}$  and  $700^{\circ}\text{C}$ , (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from the substrate outer surface, or (5) one or more free-standing carbon nanotubes originating and extending outwardly from the substrate outer surface.

As shown in Figures 1-19, carbon nanotubes of the present invention are substantially concentric tubules. The nanotubes have diameters ranging from 4 to 500 nm and lengths up to 50  $\mu\text{m}$ . Preferably, carbon nanotubes which are longer than 20  $\mu\text{m}$  have a diameter of at least 50 nm to maintain alignment. Depending upon growth conditions, the carbon nanotubes can be either free-standing nanotube obelisks which have a sharp, tapered carbon tip or a large array of well-aligned nanotubes which have a cap distally located from the substrate. The large arrays of carbon nanotubes have densities of  $10^6$  to  $10^8$  nanotubes per square millimeter of substrate. The cap comprises a catalyst metal or metal alloy material of iron, cobalt, nickel, or an alloy of iron, cobalt, or nickel. The

catalyst material and its role is discussed further below. In an embodiment of the present invention, the tips and caps are removed to reveal open-ended carbon nanotubes.

It is contemplated that a wide variety of electrically or non-electrically conductive substrates can be utilized with the present invention. For example, suitable  
5 substrates include glass, silica, quartz, silicon, platinum, iron, cobalt, nickel, an alloy of iron, cobalt, or nickel, a ceramic, or a combination thereof. Particularly useful substrates are glass panels and silicon wafers. It is important to recognize that the most important property of the substrate is that the substrate strain point and/or melting point  
10 temperatures are above the temperature of carbon nanotube growth. With the present invention, the substrate must have strain point and/or melting point temperatures of at least about 300°C. As disclosed in Li, substrates utilized in the prior art must have strain point and/or melting point temperatures in excess of 700°C. Accordingly, a product of the present invention and the substrate therein have a strain point or melting point  
15 temperature between 300°C and 700°C. Such substrates include flat panel display glass substrates, which have strain point and/or melting point temperatures of 666°C and below, may be utilized. Certain ceramics, such as LaAlO<sub>3</sub>, Al<sub>2</sub>O<sub>3</sub>, and ZrO<sub>2</sub>, YSZ, and SrTiO<sub>3</sub> have melting point temperatures of about 3000°C and are useful as substrates utilized in high temperature environments.

In the present invention, carbon nanotubes are uniquely grown on a  
20 surface of a substrate by providing the substrate in a reduced pressure environment containing a carbon source gas and a catalyst gas and exposing the substrate to a plasma under conditions effective to cause formation and growth of one or more carbon nanotubes on the substrate. This is defined as plasma-enhanced hot filament chemical vapor deposition (PE-HF-CVD). Accordingly, the present invention is also directed to  
25 products which have carbon nanotubes originating and extending outwardly from an outer surface of the substrate.

Prior to growing the carbon nanotubes by PE-HF-CVD, the substrates are placed into a deposition chamber at a reduced pressure ( $< 6 \times 10^{-6}$  Torr) and coated with the catalyst metal or metal alloys discussed above. Either a metal catalyst film of at least  
30 about 15 nm thick or one or more metal catalyst nano-dots of about 150Å thick is deposited onto the substrate. The catalyst film is deposited by radio frequency magnetron sputtering. The catalyst nano-dots are deposited by electron beam evaporation, thermal evaporation, or magnetron sputtering. Surprisingly, the resultingly grown carbon

nanotube diameters are directly related to the thickness of the catalyst film. By varying the thickness of the catalyst film, the diameter of the carbon nanotubes can be controlled. Although nano-dot thickness can have a like effect on resulting nanotube diameter, the thickness is less controlling as the film.

5                   To produce the products of the present invention, the coated substrates are placed into a reduced pressure CVD chamber containing a carbon source gas and a catalyst gas and are then exposed to a plasma under conditions effective to cause formation and growth of one or more carbon nanotubes on the substrate surface. Generally, the CVD chamber has a pressure between about 0.1 to about 100 Torr.  
10                   preferably about 1 to about 20 Torr. Because carbon nanotube growth is induced by plasma enhanced chemical vapor deposition of the carbon source gas, the heated environment of the CVD chamber can be maintained at a temperature between about 300°C and about 3000°C. As a result of the low temperature requirement, various substrates having relatively low strain point or melting point temperatures as low as about  
15                   300°C may utilized in the present invention. As indicated above, carbon nanotubes growth may occur at very high temperatures and is only constrained by the melting point temperature of the selected substrate. The upper temperature limit of carbon nanotube growth is estimated to be about 3000°C, which corresponds to the highest known ceramic substrate melting point temperature, as discussed above. The growth time depends on the  
20                   requirement of nanotube length. Normally, it is between 1 – 10 minutes, which yields a length of 0.1 – 20  $\mu\text{m}$ . Growth durations can extend up to 5 hours depending on the desired carbon nanotube lengths.

                  The carbon source and catalyst gases flow through the CVD chamber with a volume ratio of carbon source gas to catalyst gas ranging from 1: 2 to 1:10 at a  
25                   maintained pressure between about 0.1 to about 100 Torr at a temperature between about 300°C to 3000°C. The carbon source gas may be selected from saturated or unsaturated linear, branched, or cyclic carbon and hydrogen compounds having up to six carbon atoms which are gases at the deposition pressure. For example, very pure (99.99% purity) acetylene, ethylene, and benzene, preferably acetylene, may be utilized as the  
30                   carbon source gas of the present invention. The catalyst gas is ammonia (99.99% purity) at CVD temperatures below 700°C. At CVD temperatures above 700°C, the catalyst gas may be ammonia, nitrogen (99.99% purity), or a combination thereof. Ammonia is the preferred catalyst gas of the present invention. Preferably, the carbon source and catalyst

gases are introduced into the CVD chamber simultaneously or the catalyst gas is introduced prior to the carbon source gas.

Carbon nanotubes are synthesized with the diameter, length, site density, and growing angle controlled. Plasma intensity may be varied to determine the nanotube aspect ratios for diameter and length, and range of both site and height distributions. Vertical or non-vertical growth of the carbon nanotubes is independent of the substrate surface topography and can be controlled by the angle placement of the substrate in the CVD chamber with respect to the orientation of the electric field of the plasma generator.

These lower temperature growth conditions are suitable for electron emission applications, such as cold-cathode flat panel displays which require the carbon nanotube emitters to be grown substantially perpendicular to a glass substrate surface. However, carbon nanotubes grown at the lower temperatures have more wall defects or discontinuities. These discontinuities provide a diffusion path to the nanotube core. Should there be a desire to manufacture carbon nanotubes with limited defects, higher growth temperatures may be utilized.

The growth mechanism of aligned carbon nanotubes is ascribed in the literature to be a constraint of either the pores in mesoporous silica or the laser etched tracks in silica. In the present invention, the alignment of the carbon nanotubes cannot be due to pores or etched tracks since there are no pores or etched tracks in the glass substrates, as shown in Figures 5A-B, 10, 15, 17A-B, and 18C, E, and F. Rather, alignment is due to a nanotube nucleation process catalyzed by the catalyst gas (e.g., ammonia) and the catalyst layer or nano-dot (e.g., nickel). In the presence of the catalyst gas, each metal catalyst cap efficiently catalyzes the continuous synthesis of carbon nanotubes. With the growth of the carbon nanotubes, the cap is maintained at the distal end of each carbon nanotube. The alignment and thickness of the carbon nanotubes may be determined by the orientation and size respectively of the initial catalytic centers. If desired, the catalyst metal caps can be removed by subjecting the carbon nanotubes to either HNO<sub>3</sub> solution etching or Ar ion sputtering to open the distal ends.

In some applications, a single carbon nanotube or patterns with controlled site density is desired, which can be accomplished by selective deposition of the catalyst nano-dots. In the present invention, the carbon nanotubes grown from the metal catalyst nano-dots are obelisks which have tapered, sharp carbon tips and have rounded base diameters approximately the same as the nano-dots. The nanotube height depends on the

growth time and nano-dot thickness. The tips can be removed as well to provide an open ended nanotube by placing the nanotubes in a reaction chamber and exposing the nanotubes to oxygen and heat at about 400°C for about 0.5 hour.

A filling can be placed within the carbon nanotubes through the open ends  
5 or through the structural discontinuations. For example, fillings such as hydrogen, lithium ions, bismuth, lead telluride, bismuth tritelluride, or a pharmacological agent, to name only a few, may be inserted into the nanotube core by electrochemical or physical methods. If desired, the open ends of the carbon nanotubes can be enclosed or sealed by magnetron sputtering or electrochemical deposition of an enclosing material, such as a  
10 metal.

Now, referring to Figure 20, a conventional flat panel display or field emission display 100 has a baseplate 102, a spaced-apart phosphor coated faceplate 104, and an electron emitter array 106 positioned on the baseplate 102 for emitting electrons to impinge upon and thereby illuminate the phosphor coating. The baseplate 102, the  
15 faceplate 104 and the emitter array 106 are disposed in a vacuum environment. The emitter 106, which is operably connected to an electron generating source, has a sharp tip 108, known as a Spindt tip, to emit electrons. However, these emitters 106 have certain drawbacks because they have a relatively short wear life, have a low emission density due to the limits of existing lithography technology, and are relatively expensive. Products of  
20 the present invention comprising large arrays of well-aligned carbon nanotubes as shown in, for example, Figures 1, 2, 5, 7, 10, 11, and 18B, can be used to replace the base plate/emitter array combination 102 and 106. Since the carbon nanotubes can be produced highly aligned and perpendicular to the substrate, field emission displays can be fabricated utilizing such arrays as emitters. Further, as discussed in Schmid et al.,  
25 "Carbon Nanotubes Are Coherent Electron Sources," Appl. Phys. Lett., 70(20):2679-2680 (1997) ("Schmid"), Collins et al., "A Simple And Robust Electron Beam Source From Carbon Nanotubes," Appl. Phys. Lett., 69(13):1969-1971 (1996), and Rinzler et al., "Unraveling Nanotubes: Field Emission From an Atomic Wire," Science, 269: 1550-1553 (1995) ("Rinzler"), all of which incorporated herein by reference, carbon nanotubes emit  
30 electrons in the same manner as the Spindt tips upon operable connection to an electron generating source. Not only can the carbon nanotubes increase emitter wear life, contrast and brightness are improved as well due to the large nanotube density.

Referring to Figures 19, 21, and 22, and generally to Figures 1-18, the products of the present invention can be utilized as a probe for a scanning electron microscope, as indicated in Rinzier. A scanning electron microscope 200 of the present invention comprises a vacuum chamber 202 capable of receiving a specimen 204, an electron  
5 source 206 for producing electrons, a probe 208 which is operably positioned within the vacuum chamber 202 for emitting and directing the electrons toward and scanning the specimen 204, a detector 210 operably positioned within the vacuum chamber 202 for collecting radiation issuing from the specimen 204 as a result of scanning by the probe 208 to produce an output signal, and a display screen 212 operably connected to the  
10 detector 210 to receive the output signal and resulting display an image of the area of the specimen 204 scanned by the probe 208. Referring to Figures 1-5B, 7-19 and 21, the probe 208 is a product of the present invention having a substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of  
15 a density no greater than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about 300°C and 700°C; (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending  
20 outwardly from an outer surface of the substrate. Preferably, the probe 208 is a product of the present invention comprising a substrate 214 having an outer surface 216 and one free-standing carbon nanotube 218 originating and extending from the outer surface 216 of the substrate 214.

Selective positioning and growth of a single, free-standing carbon  
25 nanotube from a single, catalyst nano-dot in accordance with the method of the present invention as previously described can produce the probe 208. Referring to Figure 21, and generally to Figure 19, a single, free-standing carbon nanotube 218 originating and extending from an outer surface 216 of a substrate 214 is operably connected to the electron source 206. The substrate 214 is selected from an electrically conductive  
30 material, which is connectable to the electron source.

In operation, the specimen 204 is positioned within the vacuum chamber 202, and the chamber 202 is evacuated. The microscope 200 scans the specimen 204 with a fine probe of electrons emitting from the probe 208. The electrons are produced

from the electron source 206, which can be a field-emission electron source (not shown) and suitable accelerating electrodes (not shown), such as an electron gun (not shown). Electrons that are transmitted through the specimen 204 are collected by the detector 210 to provide the output signal. For example, the detector 210 can comprise a phosphor  
5 screen (not shown) with a photomultiplier (not shown) for detecting light from the screen. This output signal is used to modulate the beam of the display screen 212, such as a cathode ray tube, which is scanned in synchronism with the probe 208, so as to cause the display screen 212 to display a pattern which depends on the structure of the scanned portion of the specimen 204. Alternatively, instead of collecting transmitted electrons,  
10 secondary radiation (e.g., electrons or x-rays), emitted from the specimen 204 as a result of bombardment by the electrons of the probe 208, may be detected to provide the output signal.

In such a microscope, the electron fine probe or carbon nanotube 218 must be very fine, such as to illuminate only a small region of the specimen 204, in order to  
15 enable small features of the specimen 204 to be examined. Production of a fine probe of electrons requires an electron source 206 having a very small electron-emitting area such as, for example, a field-emission electron source. Magnets 220 can be operably disposed in the vacuum chamber 202 to focus or alter the emitted electron probe. Carbon nanotubes produced in accordance with the present invention are such electron emitters.

20 The products of the present invention can also be utilized to form alkali metal ion batteries, such as, lithium batteries. As shown in Figure 23, the battery 300 comprises an anode 302, a cathode 304, an insulator 306 disposed between the anode 302 and the cathode 304, and an electrolyte 308. At least one of the anode 302 and the cathode 304, preferably both, comprise a product of the present invention having a  
25 substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about 300°C and 700°C; (4) a  
30 plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate. Preferably,

the product has a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate.

Here, the substrate comprises an electrically conductive material, and the carbon nanotubes have at least one diffusion path to the hollow core of the nanotubes. As reported in Gao et al, "Electrochemical Intercalation of Single-walled Carbon Nanotubes with Lithium," Chem. Phys. Lett., (in press) ("Gao") alkali metals can be electrochemically intercalated into the hollow cores of carbon nanotubes. Gao also reports that lithium can be reversibly intercalated from the nanotubes in the range of 100-400 mAh/g. In the present invention, lithium ions may be intercalated into the carbon nanotubes of the anode 302 by charging the battery 300.

Although not required, the carbon nanotubes of the product may have open ends to provide the metal diffusion path, as shown in Figure 13. Preferably, the carbon nanotubes have high structural defect or discontinuation densities in the walls. As previously discussed, carbon nanotubes grown at low growth temperatures (e.g., 300°C to 400°C) by PE-HF-CVD have such structural discontinuations. These structural discontinuations provide high active surface areas and numerous diffusion paths to the nanotube core for metal diffusion. It is not necessary for the carbon nanotubes having discontinuations to be open-ended, since most metal diffusion occurs through the discontinuations.

In the present invention, the cathode 304 functions to assist conduction for collecting current, and the anode 302 functions as the host material for the lithium ions. Since the anode 302 and/or the cathode 304 comprises well-aligned carbon nanotubes, the electrolyte 308 easily permeates the nanotubes, which act as electrodes. As a result, impedance of the battery 300 is decreased, the charge-discharge efficiency is improved over conventional batteries, and secondary reactions during charge and discharge are prevented. Thus, the battery 300 of the present invention has a high capacity and a long life cycle.

When the cathode 304 comprises the product of the present invention having intercalated lithium ions, a higher collecting ability can be attained. As a result, the utilization of the cathode 304 can be increased to produce a high-capacity lithium battery 300.

Products of the present invention having carbon nanotubes substantially aligned and oriented substantially perpendicular with respect to the substrate are



preferred. By utilizing such products, the electrolyte 308 can permeate the nanotubes much easier. This results in the battery 300 being capable of rapid charge and discharge. In the anode 302, lithium can be deposited on the carbon nanotubes surfaces and intercalated into the nanotubes, thereby preventing the growth of dendritic lithium metal deposition and resulting in the battery 300 having a higher capacity. Also, when the products of the present invention are used as an anode 302 for intercalating and deintercalating lithium ions, a high-capacity anode 302 is formed.

Again referring to Figure 23, the anode 302 and the cathode 304 are disposed in the electrolyte 308 held in a housing 310 opposite to each other through the insulator 306. The insulator 306 is provided for preventing internal shorts due to contact between the anode 302 and the cathode 304. The anode 302 and the cathode 304 respectively can comprise the products shown in Figures 1-19. An anode terminal 312 and a cathode terminal 314 are electrically connected to the respective product substrates comprising the anode 302 and the cathode 304. The anode terminal 312 and the cathode terminal 314 may be utilized for at least a portion of the housing 310. When a lithium battery 300 of the present invention is assembled, the anode 302 and cathode 304 must be sufficiently dehydrated and dried. For example, dehydration can be performed by heating under reduced pressure.

The carbon nanotubes serve as the collecting electrodes of the anode 302 and the cathode 304. The nanotubes function to efficiently supply a current to be consumed by electrode reaction during charge and discharge or to collect the current generated by the electrode reaction.

The insulator 306 functions to prevent internal shorts between the anode 302 and the cathode 304, and can function to hold the electrolyte 308. The insulator 306 must have pores which permit movement of lithium ions, and must be insoluble and stable in the electrolyte 306. Thus, examples of materials which may be used for the insulator 306 include glass, polyolefins, such as polypropylene and polyethylene, fluororesins, and materials having a micropore and nonwoven fabric structure. A metal oxide film having micropores and a resin film compounded with a metal oxide can also be used.

An electrolyte solution is prepared by dissolving the electrolyte 308 in a solvent. Examples of electrolytes 308 include acids, such as  $\text{H}_2\text{SO}_4$ ,  $\text{HCl}$ , and  $\text{HNO}_3$ , salts comprising lithium ions and Lewis acid ions ( $\text{BF}_4^-$ ,  $\text{PF}_6^-$ ,  $\text{ClO}_4^-$ ,  $\text{CF}_3\text{SO}_3^-$ , and  $\text{BPh}_4^-$ ).

and salt mixtures thereof. Salts comprising cations such as sodium ion, calcium ion, and tetraalkylammonium ion, and the Lewis acid ions can also be used. These salts can be sufficiently dehydrated and deoxidized by heating under reduced pressure.

- Examples of solvents which are useful for the electrolyte 308 include
- 5 acetonitrile, benzonitrile, propylenecarbonate, ethylenecarbonate, dimethylcarbonate, diethylcarbonate, dimethylformamide, tetrahydrofuran, nitrobenzene, dichloroethane, diethoxyethane, 1,2-dimethoxyethane, chlorobenzene, gamma -butyrolactone, dioxolan, sulfolan, nitromethane, 2-methyltetrahydrofuran, 3-propylsydnone, sulfurdioxide, phosphorylchloride, thionylchloride, sulfurylchloride, and solvent mixtures thereof.
- 10 These solvents can be dehydrated by activated alumina, molecular sieves, phosphorus pentaoxide, or calcium chloride. Some of the solvents are also subjected to removal of impurities and dehydrated by distillation in coexistence with an alkali metal in an inert gas.

- To prevent electrolyte 308 leakage, the electrolyte 308 can be formed into
- 15 a gel. Polymers which absorb the solvent of the electrolyte 308 and swell may be used as a gelling agent. For example, such polymers include poly(ethyleneoxide), poly(vinylalcohol), polyacrylamide, and the like.

- The products of the present invention may be utilized to form fuel cells. A fuel cell is a device for directly converting the chemical energy of a fuel into electrical
- 20 energy. There are various constructions of fuel cell devices, such as fuel cells, fuel cell groups or stacks, and fuel cell power plants which use hydrogen as the fuel for the respective fuel cell device. As is well known, an exothermic chemical reaction takes place in these fuel cell devices between hydrogen and an oxidant, for example, oxygen, resulting in the formation of water as the reaction product and the desired generation of
- 25 electricity. The incidental release of thermal energy exhibited as sensible heat is typically removed from the fuel cell. During the above reaction, hydrogen and the oxidant are consumed by the fuel cell. For the fuel cell device to continue its operation, hydrogen and the oxidant must be replenished at their respective consumption rates.

- In some fuel cell applications, hydrogen is stored in tanks or similar
- 30 containers in its liquid or gaseous state in its pure form or in combination with inert substances. However, such containers are generally relatively large and heavy, and problematic when storage space and/or payload weight are limited. Thus, there is an

advantage when large amounts gaseous hydrogen can be stored in compact, relatively light weight containers.

Referring to Figure 24, a fuel cell 400 of the present invention comprises a housing 402, two gas diffusion electrodes, an anode 404 and a cathode 406, positioned within the housing 402 and respectively forming an anode side 408 and a cathode side 410, an electrolyte impregnated matrix or ion exchange membrane 409 positioned between and in electrical contact with the electrodes 404 and 406, an external circuit 412 electrically and operably connecting the anode 404 to the cathode 406 and a hydrogen storage unit 414 comprising products 416 of the present invention positioned within an enclosure 418 which is operably connected to the anode side 408. A catalyst layer is disposed on the electrolyte-facing surfaces of the respective electrodes 404 and 406. In the operation of the fuel cell 400, hydrogen gas is fed to the back side of the anode 404, and oxygen gas is fed to the back side of the cathode 406. The respective gases diffuse through the electrodes 404 and 406 and react at the catalyst sites to yield electrical energy, heat, and moisture.

On the anode side 408 of the fuel cell 400, hydrogen is electrochemically oxidized to give up electrons in accordance with the reaction:  $2\text{H}_2 \rightarrow 4\text{H}^+ + 4\text{e}^-$ . The electrical current so generated is conducted from the anode 404 through the external circuit 412 to the cathode 406. On the cathode side 410 of the fuel cell 400, the electrons are electrochemically combined with the oxidant in accordance with the reaction:  $\text{O}_2 + 4\text{H}^+ + 4\text{e}^- \rightarrow 2\text{H}_2\text{O}$ . The related flow of electrons through the electrolyte completes the circuit.

Referring additionally to Figures 1-19, the hydrogen storage unit 414 comprises the enclosure 418 and products 416 of the present invention having a substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about  $300^\circ\text{C}$  and  $700^\circ\text{C}$ ; (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate. The carbon nanotubes have a hollow core and at least one diffusion path into the core. Preferably, the product

416 has plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate with a high discontinuation density in the nanotube structure to provide a plurality of diffusion paths. Further, the carbon nanotubes of this product 416 can have an open end distal from the substrate. Particularly useful are  
5 single-walled carbon nanotubes of the present invention which have a diameter of 1 nm. These nanotubes form bundles and are strong hydrogen gas absorbers. Hydrogen can be introduced into the carbon nanotube hollow core by placing the product 416 in a high pressure chamber (not shown) and introducing hydrogen gas at relatively high pressures into the chamber to diffuse hydrogen across the diffusion paths into the carbon nanotubes.  
10 Also, hydrogen can be diffused into the nanotubes electropotentially or electrochemically. Further, heated products 416 can be placed into a hydrogen rich environment and allowed to cool, thereby drawing hydrogen into the nanotubes. Because the light-weight carbon nanotubes of the present invention have relatively large cores and surface areas, large amounts of hydrogen can be stored therein.

15 The products of the present invention can also be utilized to form composites with other dissimilar materials. Suitable dissimilar materials include metals, ceramics, glasses, polymers, graphite, and mixtures thereof. Such composites are prepared by coating the products of the present invention with these dissimilar materials in solid particulate form or in liquid form.

20 A variety of polymers, including thermoplastics and resins, can be utilized to form composites with the products of the present invention. Such polymers include, for example, polyamides, polyesters, polyethers, polyphenylenes, polysulfones, polyurethanes, or epoxy resins.

In another embodiment, the composite contains an inorganic material, e.g.,  
25 a ceramic material or a glass. For example, a high-temperature copper oxide superconductor ceramic materials, such as BiSrCaCuO (BSCCO), TlBaCaCuO (TBCCO),  $\text{Bi}_2\text{Sr}_2\text{CaCu}_2\text{O}_8$  (Bi-2212),  $\text{Bi}_2\text{Sr}_2\text{Ca}_2\text{Cu}_3\text{O}_{10}$  (Bi-2223),  $\text{Tl}_2\text{Ba}_2\text{CuO}_6$  (Tl-2201),  $\text{Tl}_2\text{Ba}_2\text{CaCu}_2\text{O}_8$  (Tl-2212),  $\text{Tl}_2\text{Ba}_2\text{Ca}_2\text{Ca}_2\text{Cu}_3\text{O}_{10}$  (Tl-2223),  $\text{TlBa}_2\text{CaCu}_2\text{O}_7$  (1212),  $\text{TlBa}_2\text{Ca}_2\text{Cu}_3\text{O}_9$  (Tl-1223), and any ceramic composition derived from these  
30 compositions, such as partial replacement of Tl by Bi, Pb, Bi, or Pb, Ba by Sr, and Ca by Y or Cr., are useful in the present invention. These ceramics are deposited on the products of the present invention by magnetron sputtering, laser ablation, thermal spraying, electron beam evaporation, etc. to coat the substantially perpendicular, aligned

carbon nanotubes can form a high temperature superconducting material. Due to the high degree of nanotube alignment, excellent magnetic flux line core-pinning interaction can be obtained to enhance critical current densities ( $J_c$ ) without destroying an unnecessary volume fraction of the superconductor.

5 As discussed in Yang et al., "Nanorod-Superconductor Composites: A Pathway to Materials with High Critical Current Densities," Science, 273: 1836-1840 (1996), incorporated herein by reference, large-scale applications of the high-temperature copper oxide superconductor ("HTSC") materials listed above require high  $J_c$  at temperatures near the boiling point of liquid nitrogen to be technologically useful. By  
10 inserting columnar defects into the HTSC materials, high  $J_c$  can be maintained at higher temperatures when subjected to an electric current. The columnar defects can be accomplished by coating products of the present invention with the HTSC materials. Accordingly, a high temperature superconductor comprises a product having a substantially non-electrically conductive substrate and either (1) a plurality of  
15 substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about 300°C and 700°C; (4) a plurality of substantially aligned  
20 carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate, a high-temperature copper oxide superconductor material in admixture with the product, and at least two spaced apart terminals connectable to an electric circuit, whereby the product and the high-temperature  
25 copper oxide superconductor material admixture are subjectable to an electric current.

In still another embodiment, the composite includes a metal. Suitable metals include aluminum, magnesium, lead, zinc, copper, tungsten, titanium, niobium, hafnium, vanadium, and alloys thereof.

Referring to Figure 25 and generally to Figures 1-5B and 7-19, an  
30 electromagnetic interference (EMI) shield 500 is formed from a product of the present invention comprising a substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$

nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about 300°C and 700°C; (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate and a dissimilar material in admixture with the product. The dissimilar material comprises a polymer, graphite, or a combination thereof. Such polymers are thermoplastics and resins and can include, for example, polyamides, polyesters, polyethers, polyphenylenes, polysulfones, polyurethanes, or epoxy resins. The electromagnetic interference shield 500 is operationally positioned with respect to either an electromagnetic source 502 or an electronic component 504.

The composite can be used as an EMI shielding material in the construction of gaskets, housings for electronic components, including components within computers, conducting cables, and shielded rooms. EMI emission sources 502, and other applications known in the art. Depending upon the substrate selected for the product, such an EMI shield 500 is particularly useful in high temperature environments. In a process for shielding an electronic component 504 against EMI produced by the electromagnetic radiation source 502, the EMI shield 500 of the present invention is interposed between the electronic device 504 and the electromagnetic radiation source 502. Interference of the device 504 by the radiation source 502 is thereby substantially reduced or eliminated. A shielded electronic component 504 for resisting EMI generated by the electromagnetic source 502 has an electronic component 504 and a EMI shield 500 of the present invention operatively positioned with respect to the component 504. A shielded electromagnetic emission source 502 has an EMI emitting source 502 and EMI shield 500 of the present invention operatively positioned with respect to the source 502.

Still, the products of the present invention can as well be utilized to form a microelectrode 600, as shown in figure 26 and discussed in Stulik et al., "Microelectrodes: Definitions, Characterization and Hints For Their Use," IUPAC Commission, 5: Document No. 550/61/97 (1999), incorporated herein by reference. The microelectrode 600 comprises a product having a substantially non-electrically conductive substrate 602 and either (1) a plurality of substantially aligned carbon nanotubes 604 of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes 604 of a density no greater than

10<sup>2</sup> nanotubes per square millimeter of a substrate: (3) one or more carbon nanotubes 604, wherein the substrate 602 has a strain point or melting point temperature between about 300°C and 700°C; (4) a plurality of substantially aligned carbon nanotubes 604 originating and extending outwardly from an outer surface of the substrate 602; or (5) one or more free-standing carbon nanotubes 604 originating and extending outwardly from an outer surface 606 of the substrate 602 and at least one electrically conductive microfiber 608 operably connected to at least one carbon nanotube 604 of the product, wherein the at least one carbon nanotube 604 is operably and electrically connectable to an electric circuit.

Particularly well suited for use as an electrode or an array of electrodes are carbon nanotubes having open ends, as shown in Figure 13. The carbon nanotubes are grown on a non-electrically conductive substrate, such as glass, quartz, or a ceramic. The carbon nanotubes are operably and electrically connectable to an electric circuit with electrically conductive microfibers, such as, platinum or carbon microfibers, attached to the nanotubes.

## EXAMPLES

### Example 1

Polished polycrystalline and single-crystal Ni substrates were placed into a chemical vapor deposition (CVD) chamber, and the pressure was reduced to  $< 6 \times 10^{-6}$  Torr. Acetylene gas (99.99 % purity) and ammonia gas (99.99 % purity) were introduced into the chamber at a total flow rate of 120-200 standard cm<sup>3</sup> per minute (sccm) and at a maintained working pressure of 1-20 Torr under the conditions listed in Table 1. After stabilizing the working pressure, a tungsten filament coil powered by a DC source (a 0-500 V DC, 3 A power supply, Advanced Energy MDX 1.5K-magnetron drive) and a plasma-generator were energized to generate heat and plasma at a temperature below 666°C to induce carbon nanotube growth. Samples of the carbon nanotubes were examined by scanning electron microscopy (SEM, Hitachi S-4000) to measure tube lengths, diameters, site distributions, alignment, density and uniformity. High-resolution transmission electron microscopy (TEM) was used to determine the microstructure of individual tubes. Further, the samples were also examined by x-ray diffraction. Raman

spectroscopy, and x-ray photoemission spectroscopy to study the structure, crystallinity, composition, and central core and tube wall structures.

**Table 1.** Growth conditions for the nanotubes shown in Figures 1(A), 1(B), 2, and 3.

	C <sub>2</sub> H <sub>2</sub> / NH <sub>3</sub> (sccm / sccm)	Filament Current (amperage, A)	Plasma Intensity (amperage / voltage / watts)	Growth Time (minutes)
5				
10	(A): For Figures 1(A) and 1(B): 20 / 100	9	0.09 / 460 / 50	90
15	(B): For Figure 2: 80 / 160	9	0.2 / 640 / 140	25
20	(C): For Figure 3: 40 / 80	6	0.3 / 700 / 220	20

Figure 1A is a scanned image of an SEM micrograph showing the alignment of carbon nanotubes on polycrystalline nickel grown under the conditions described in Table 1(A). As observed, the carbon nanotubes are oriented perpendicular to the substrate surface and are quite uniform in height. The carbon nanotubes do not grow well along the Ni grain boundaries, shown by the two empty tracks running from upper left and from upper right down to bottom. This is probably due to the fact that grain boundaries do not have enough available nickel as a catalyst. Figure 1B is a higher magnification image of an area within a single nickel grain. Here, nanotube distribution uniformity within this grain is reasonably good. Although there is a wide distribution of carbon nanotube diameters ranging from 60 - 500 nm, the uniformity in both diameter and site distributions can be controlled via the growth conditions. Here, carbon nanotube density is about  $10^6$  nanotubes/mm<sup>2</sup>.

Figure 2 is a scanned image of an SEM micrograph showing carbon nanotubes grown on polycrystalline nickel at a higher plasma intensity under the conditions listed in Table 1(B). Most of the nanotube diameters are smaller (~ 250 nm), and their distribution is narrower, ranging from 200 to 300 nm. With increased plasma intensity, the density increased to  $4 \times 10^6$  nanotube/mm<sup>2</sup>, about 4 times higher than that shown in Figure 1. The increase of plasma intensity apparently reduces the catalytic



nickel particle size, which leads to both thinner carbon nanotubes and improved nanotube uniformity.

Figure 3 is a scanned image of an SEM micrograph showing carbon nanotubes grown under the conditions listed in Table 1(C). These carbon nanotubes were synthesized at a higher plasma intensity than that used for the carbon nanotubes of Figure 2. In order to keep the substrates at low temperature, the filament current was reduced from 9 to 6 amperes. As shown in Figure 3, the carbon nanotubes are at least 10  $\mu\text{m}$  long, and the diameters are  $< 100$  nm. By increasing plasma intensity, two structural changes are readily observed. First, there is a substantial decrease in the average tube diameters from  $\sim 250$  nm, as shown in Figure 2, to  $\sim 100$  nm, as shown in Figure 3. Second, the tube lengths increase dramatically. This high growth rate is very attractive for the potential large-scale production of carbon nanotubes with long lengths. However, when the diameters are  $< 20$  nm, the tubes are less straight than for those with diameters  $> 50$  nm.

High resolution transmission electron microscopy (TEM) analysis of the carbon nanotubes shows these film structures to be truly carbon nanotubes, as opposed to carbon fiber-like structures. Samples with carbon nanotubes grown to several microns in length were scraped off a nickel substrate directly onto a copper TEM grid for analysis. Figure 4 shows a typical image obtained for these carbon nanotubes. The disorder is due entirely to the random process of nanotube collection on the TEM grid. The dark spot at the end of each structure is a cap of a small ball of catalyst layer material, nickel in the instant example. This image is typical to those reported elsewhere demonstrating a carbon nanotube structure. Nevertheless, the insert to Figure 4, a high-resolution image of a portion of a typical carbon nanotube structure, is more convincing. The width of this tube is  $\sim 30$  nm and represents a highly defected multi-walled structure with a hollow core. The core diameter is about 20 nm and the wall thickness is about 5-10 nm. The fringes on each side of the tube identify individual cylindrical graphitic layers. This particular carbon nanotube is a structure with approximately 15 walls of graphitized carbon. Both the angular bend in the structure and the appearance of carbon walls running across the diameter of the nanotube demonstrate structural defects suggestive of twisting of the nanotube structure. As can be seen at the structural defects, non-continuous walls intersect one another. On an atomic scale, the defects create active surface sites for permeability through the nanotube structure. The lack of fringes inside

the nanotube, as well as the lighter contrast as compared to the nanotube walls, indicates that the core of the structure is hollow.

### Example 2

#### Substrate Preparation

5           Display glass having a strain point temperature of 666°C was cut into 10 x 5 mm pieces and cleaned in acetone by ultra-sonication. The cleaned pieces were mounted onto the surface of a stainless steel resistive heater, and the whole assembly was placed into a magnetron sputtering chamber. The chamber was pumped down below  $8 \times 10^{-6}$  Torr before argon gas was introduced into the chamber to maintain a working  
10          pressure of 20-60 mTorr. A nickel catalyst layer of 15 to 60 nm in thickness was deposited onto the glass substrates by magnetron sputtering for about 1.5 to 6 minutes. During deposition, the substrates were either heated or kept at room temperature.

            Catalyst layered substrates were placed to a CVD chamber, which was pumped down below  $6 \times 10^{-6}$  Torr. As soon as the chamber pressure reached  $6 \times 10^{-6}$   
15          Torr, acetylene and ammonia gases were introduced into the chamber to maintain a working pressure of 1 – 20 Torr during carbon nanotube growth. The total flow rate of acetylene and ammonia gases was 120 – 200 sccm with a volume ratio of acetylene to ammonia varying from 1: 2 to 1:10. After the working pressure stabilized, the power to the tungsten filament coil and to the plasma-generator, as described in Example 1, were  
20          energized to generate heat and plasma at a temperature below 666°C to induce carbon nanotube growth under the conditions listed in Table 2. Carbon nanotube samples were examined in the manner described in Example 1. In particular, scanning electron microscopy was used to investigate the effect of various growth conditions on the morphology of carbon nanotubes grown on nickel-coated display glass.

25           As described in Table 2(A),  $\text{NH}_3$  was introduced during the first 5 minutes without introducing  $\text{C}_2\text{H}_2$ . During this time, the catalyst layer was plasma etched to reduce its thickness to less than 40 nm. After these initial 5 minutes,  $\text{C}_2\text{H}_2$  was introduced. Immediately, a color change occurred as a result of the growth of carbon nanotubes. The growth period lasted only 10 minutes. Referring to Figures 5A-B, in  
30          order to examine the orientation and alignment of the carbon nanotubes on the glass substrates, part of the carbon nanotube-covered area was peeled off (lower left in Figure 5A) with a tweezer to expose the glass substrate. During peeling, another area was crumpled (lower right in Figure 5A), and a long scratch was made on the peeled open

area (lower left in Figure 5A). Under visual and SEM observations, the alignment of the carbon nanotubes across the whole surface was as uniform as in the upper part of Figure 5A. To estimate the carbon nanotube length, an SEM was taken at higher magnification along the peeled edge (Figure 5B). Misalignment of the carbon nanotubes on the peeled  
5 edge resulted from the peeling operation. From Figure 5B, it was estimated that the nanotubes were about 100 nm in diameter and 20  $\mu\text{m}$  in length. Given the growth time of 10 minutes, the growth rate was calculated to be 120  $\mu\text{m}$  / hour, about 5 times faster than the value reported in Li.

As respectively shown in Figures 6A and 6B, the surfaces of the nickel  
10 layer after the initial  $\text{NH}_3$  or  $\text{N}_2$  plasma etching are essentially the same. The plasma etching conditions are respectively listed in Table 2(B) and 2(C). For comparison, Figure 6C shows the as-sputtered smooth nickel surface. Although both  $\text{NH}_3$  and  $\text{N}_2$  plasma etching roughen the nickel surface, the roughing of the nickel surface is not responsible for the nucleation and growth of carbon nanotubes.

15 Interestingly, when the sequence of gas introduction is reversed, that is, when  $\text{C}_2\text{H}_2$  is introduced first, 5 minutes later, followed by  $\text{NH}_3$ , no growth of carbon nanotubes is observed, only amorphous carbon is formed on the nickel surface. The amorphous carbon layer forms in the first 5 minutes and  $\text{C}_2\text{H}_2$  plasma covered the nickel surface to inhibit the catalytic role of nickel so that there is no growth of carbon  
20 nanotubes. Apparently, carbon nanotubes grow only when catalyst gas ( $\text{NH}_3$ ) is introduced first followed by the carbon source gas ( $\text{C}_2\text{H}_2$ ) or both the carbon source and catalyst gases ( $\text{C}_2\text{H}_2$  and  $\text{NH}_3$ , respectively) are introduced simultaneously. Thus, it may be concluded that  $\text{NH}_3$  plays a crucial catalytic role together with the nickel layer to promote the growth of the carbon nanotubes. The catalytic role of  $\text{NH}_3$  is further  
25 confirmed by the fact that there is no carbon nanotube growth when  $\text{NH}_3$  was replaced by  $\text{N}_2$  gas at temperatures below 700°C with other conditions unchanged. However, carbon nanotubes do grow when  $\text{NH}_3$  is replaced by  $\text{N}_2$  at temperatures above 700°C utilizing PE-HF-CVD.

In order to examine the effect of thickness of the metal catalyst layer on  
30 the growth of carbon nanotubes,  $\text{C}_2\text{H}_2$  and  $\text{NH}_3$  were introduced at the same time under the conditions listed in Table 2(D). Under these growth conditions, no plasma etching occurred, and the nickel layer remained 40 nm thick.

Referring to Figure 7A, carbon nanotubes have an estimated site density of about  $10^7$  tubes/mm<sup>2</sup>. The diameters of the carbon nanotubes (Figure 7A) are much larger than those in Figure 5B. From Figure 7B, it is estimated that the outside diameters of the carbon nanotubes range from 180 to 350 nm, and most of the carbon nanotubes are about 250 nm in diameter. Although not shown, carbon nanotubes have been grown in accordance with this method with diameters as large as 500 nm. This experiment clearly shows that as the catalyst layer thickness is reduced, the diameters of the resultingly grown carbon nanotubes are likewise reduced. As shown in Figure 7B, the catalytic role of nickel is also clearly indicated by the nickel cap on the tip of each nanotube.

Interestingly, one carbon nanotube, as indicated by an arrow in Figure 7B, does not have a nickel cap. Due to the absence of a cap on the identified nanotube, it may be concluded that the carbon nanotubes are empty with a very thin wall. In support of this conclusion, another carbon nanotube is viewable behind the capless one through its wall. Surprisingly, the nanotubes have a central core which is larger than reported values in literature. These large carbon nanotubes may be useful for applications such as storage of gases, such as H<sub>2</sub>, and as microelectrodes.

These experiments show a direct relationship between metal catalyst layer thickness and nanotube diameters. That is, the thinner the nickel layer, the thinner the nanotubes. To examine further the effect of nickel layer thickness on carbon nanotube growth, a much thinner nickel layer of only 15 nm is utilized under the conditions listed in Table 2(E) and 2(F). In one experiment (Table 2(F)), the nickel layer thickness is plasma etching reduced by introducing NH<sub>3</sub> first, and 20 minutes later introducing C<sub>2</sub>H<sub>2</sub>. In Figures 8A and 8B, respectively, SEM micrographs of carbon nanotubes grown under the conditions listed in Table 2(E) and 2(F) show the dependent relationship of nanotube diameter to the nickel layer thickness. The typical diameter of the nanotubes in Figure 8A is only about 65 nm, compared to 240 nm in Figure 7B. Relatively speaking, the alignment in Figure 8A is not quite as good as in Figure 7B. A comparison of Figures 8A and 8B demonstrates that 20 minutes of plasma etching reduces the thickness of nickel layer, which in turn results in even thinner carbon nanotubes with typical diameters of only about 20 nm. The comparison also shows that the alignment begins to deviate when the nanotube diameter is reduced to 20 nm. Carbon nanotubes have been produced in accordance with this method having a diameter as small as 4 nm. Therefore, for

applications requiring substantial nanotube alignment, it is apparent that diameters should be larger than 50 nm for carbon nanotubes having a length of 20  $\mu\text{m}$  or longer.

Again, high-resolution TEM was utilized to determine the interior and wall structures of the carbon nanotubes. Samples for a plan view TEM were prepared as follows. Given the flexible nature of the nanotubes, the carbon nanotube film was penetrated with M-Bond 610 epoxy resin (M-Line Accessories) to provide mechanical stiffness. This resin has very low viscosity and curing is time/temperature dependent. Hydrotetrafurane (diethylene oxide) makes up about 90% of the composition of M-Bond. The carbon nanotube film was immersed in acetone; then M-Bond epoxy is slowly added until a 1:1 ratio is attained. The sample was cured at room temperature for 48 hours. Because the viscosity of the epoxy was very low when introduced to the sample, it easily impregnated the pores to completely mix with the acetone. Standard mechanical thinning and ion milling (low angle, low voltage and current) was used to thin the sample to electron transparency. Most of the substrate was removed mechanically, followed by ion milling until the film was exposed. Then, both sides were ion milled for 15 minutes.

Figure 9A shows a cross-sectional view of a typical thinner carbon nanotube. This carbon nanotube is a multi-walled central hollow tube with an outside diameter of nearly 30 nm. The fringes on each side of the tube represent individual cylindrical graphitic layers. This particular carbon nanotube has approximately 15 walls of graphitized carbon. Both the angular bend in the structure and the appearance of carbon walls running across the diameter of the nanotube demonstrate structural defects suggestive of twisting of the nanotube structure. The lack of fringes inside the tube, as well as the lighter contrast compared to the nanotube walls indicates that the core of the structure is hollow.

Further evidence of the hollow core is shown in Figure 9B. This is a high-resolution plan view TEM image of a single carbon nanotube structure. Here, the hollow nature of the nanotube, again represented by the lighter contrast of the inner core, is more readily observable. The disorder seen in the wall fringes circumventing the hollow center are most likely caused by the twist-like defects throughout the carbon nanotube length as shown in Figure 9A. These high-resolution TEM images show that the structures are hollow, multi-walled carbon nanotubes with defects existing along the tube. The defects of bending and twisting of the carbon nanotubes of the thin carbon nanotubes shown in Figures 9A and 9B are consistent with the SEM observation in Figure 8B. Further, there

is a inverse relationship between CVD temperature and defect density. As the deposition temperature is reduced, the carbon nanotubes demonstrate an increase in the number of defects which occur in the wall. On an atomic scale, these defects render the wall of the carbon nanotube discontinuous. This results in an extremely high, active, and accessible surface area due to the substantial alignment of and relatively large spacing between the carbon nanotubes. These discontinuations in the wall structure provide atomic disorder which results in an active surface through which atomic level diffusion can occur.

**Table 2.** Growth conditions for nanotubes shown in Figures 5, 6, 7, and 8.

	C <sub>2</sub> H <sub>2</sub> / NH <sub>3</sub> / N <sub>2</sub> (sccm / sccm)	Filament Current (amperage, A)	Plasma Intensity (amperage / voltage / watts)	Growth Time (minutes)
	(A): For Figures 5A and 5B:			
15	0 / 160 / 0	8.5	0.10 / 635 / 72	5
	followed by 80 / 160 / 0	8.5	0.13 / 670 / 95	10
	(B): For Figure 6A:			
20	0 / 160 / 0	8.5	0.09 / 740 / 66	3
	(C): For Figure 6B:			
	0 / 0 / 296	8.5	0.10 / 480 / 53	3
25	(D): For Figures 7A and 7B:			
	80 / 160 / 0	8.5	0.20 / 700 / 150	25
	(E): For Figure 8A:			
30	40 / 160 / 0	7.2	0.13 / 650 / 90	14
	(F): For Figure 8B:			
	0 / 160 / 0	8.0	0.10 / 480 / 52	20
35	followed by 80 / 160 / 0	8.2	0.10 / 560 / 60	10

### Example 3

A glass substrate was prepared as in Example 2 with a 10-40 nm thick nickel catalyst layer having an as-sputtered smooth surface, as shown in Figure 6C.

Carbon nanotubes were grown by PE-HF-CVD for about 10 minutes as in Examples 1 and 2, except the acetylene and ammonia volume ratio was 1:2 to 1:4. Figure 10 shows a large area growth of substantially vertically aligned carbon nanotubes. The length of the

carbon nanotubes is up to 50  $\mu\text{m}$ . The diameters are estimated to be in the range of 100 – 150 nm (See Figure 14).

#### Example 4

Single crystal, p-type boron doped 9.5  $\Omega\text{-cm}$  (100) silicon substrates were  
5 prepared as in Example 2 with a 10-40 nm thick nickel catalyst layer having an as-sputtered smooth surface, as shown in Figure 6C. Carbon nanotubes were grown by PE-HF-CVD as in Examples 1 and 2, except the acetylene to ammonia volume ratio was 1:2 to 1:4. Figures 11 and 12 show carbon nanotubes which were grown for 5 and 2 minutes, respectively. Referring to Figure 11, substantially perpendicular carbon nanotube  
10 alignment is clearly shown. A nickel cap, which acts as a catalyst to sustain growth, is also discernible at the top of each carbon nanotube. Early stage carbon nanotube growth is shown Figure 12, since the growth was stopped at 2 minutes. The shortest nanotubes are about 0.1  $\mu\text{m}$ .

#### Example 5

15 Carbon nanotubes were grown as in Example 3. The catalyst metal caps were thereafter removed by  $\text{HNO}_3$  solution etching and Ar ion sputtering. Figures 13 and 14 show the SEM image of the nanotubes after removal of the nickel caps by  $\text{HNO}_3$  solution etching and Ar ion sputtering, respectively. The solution etching by  $\text{HNO}_3$  only took about one minute, and the removal of nickel caps is complete. As shown in Figure  
20 13, the ends of the carbon nanotubes are open after etching. Morphologically, there was no observable damage by the  $\text{HNO}_3$  etching. In Figure 14, all the nanotubes were bent by the Ar ion sputtering, and the nickel caps were not completely removed. These techniques may be utilized to remove any of the metal or metal alloy caps. By removing the caps, various fillings (i.e. hydrogen, lithium ions, bismuth, lead telluride, bismuth  
25 tritelluride, a pharmacological agent, etc.) can be added to the nanotube core. Thereafter, if desired, the open ends can be sealed by electrochemical deposition of a metal onto the carbon nanotubes.

#### Example 6

Carbon nanotubes were grown as in Example 3, except the substrates were  
30 placed in the CVD chamber at differing angles with respect to the plasma generator. Although the carbon nanotubes grew substantially aligned with one another, the alignment was independent of substrate surface topography. Figures 15 and 16 show the

SEM image taken from side and top on a sample sit tilted at a certain angle during growth. It is observed that carbon nanotube alignment is not perpendicular to the substrate surface, but rather is angled with respect to the substrate. The tilt direction is closely related to the direction of the electrical field which generates the plasma. This  
5 technique may be utilized to grow aligned carbon nanotubes at any angle with respect to the substrate, including nanotubes lying in a plane.

#### Example 7

A catalyst layer of nickel was deposited on a p-type boron doped 9.5  $\Omega$ -cm (100) silicon substrate by electron beam lithography and metal evaporation. A bilayer  
10 electron-beam resist (5% 100 molecular weight polymethylmethacralate) was capped by 2% 950 molecular weight polymethylmethacralate that was patterned with a JEOL J6400 SEM converted for lithography. The resist was developed in a solution of methyl isobutyl ketone and isopropyl alcohol (3:1). Thereafter, 150Å of nickel was deposited by electron beam evaporation. A catalyst layer (i.e. a large,  $\sim 0.25 \text{ mm}^2$  nickel pad or one or  
15 more nano-dots) remained after resist/metal liftoff in acetone.

Carbon nanotubes were grown by PE-HF-CVD as in the process in Example 2, except growth was performed at a pressure of 1-10 Torr with an acetylene to ammonia volume mixture of 1:4 at a total flow rate of 200 sccm for about 5 minutes.

Referring to Figures 17A-B, scanned images of SEM micrographs show  
20 carbon nanotubes grown on the silicon substrate in the region of the edge of the nickel pad. As shown in Figure 17A, absence of nanotube growth in the foreground demonstrates selective growth on the nickel catalyst film and not on the silicon substrate. Figure 17B shows these nanotubes after being mechanically broken using tweezers. Surprisingly, the tubes break somewhere along the tube and not at the interface between  
25 the nickel and silicon. This observation is different that that of nickel-on-glass nanotube growth, where the nanotubes broke cleanly at the nickel-glass interface, as shown in Figure 5A.

#### Example 8

Nickel catalyst nano-dot patterns were deposited on a p-type boron doped  
30 9.5  $\Omega$ -cm (100) silicon substrate by electron beam lithography and metal evaporation as in Example 7. Carbon nanotubes were grown by PE-HF-CVD as in the process in Example 7, except the growth temperature was between 300°C and 666°C and only a



single, free-standing carbon nanotube grew on each nickel nano-dot. Thereafter, carbon samples were examined by SEM, TEM, XPS, etc. techniques as discussed above.

Figure 18 is a series of SEM micrographs illustrating the growth of single, multiwall carbon nanotube obelisks on respective nickel catalyst nano-dots. The catalyst nano-dots are shown in arrays of ~100 nm catalyst nano-dots. The site and spacing are precisely controlled. Figures 18A, 18C, 18E, and 18F are perspective views of the nanotubes, and Figures 18B and 18D are top views of the nanotubes. Figures 18A and 18B demonstrate selective growth of the nanotubes on the several repeated array patterns. The nanotubes accurately reflect the spacing and periodicity of the lithographically patterned catalyst nano-dots. Figures 18C and 18D reflect higher magnification and show the repeated array pattern where the nanotubes are spaced either 2  $\mu\text{m}$  apart (left portion of array) or 1  $\mu\text{m}$  apart (right portion of array).

The sharp, tapered tips of the nanotubes shown in Figures 18E, 18F, and 19 are unique to carbon nanotubes grown on nano-dots under the instant conditions. Notably, such nanotubes do not have a cap of the catalyst material. In Figure 18F, the nano-dots are spaced 5  $\mu\text{m}$  apart. The non-uniformity of height (0.1 to 5  $\mu\text{m}$ ) is apparently not related to the spatial position. Rather, it is believed to be due to non-uniform electron beam lithography and electron beam evaporation of the catalyst nano-dots onto the substrate. With precise control of the electron beam lithography, all carbon nanotubes should be substantially uniform in height. Nanotube length is dependent upon the growth time and the thickness of the nano-dot, whereas nanotube diameter depends upon the diameter of the nano-dot. It can be observed that although the heights vary, the diameters are generally uniform at ~150 nm. By utilizing controlled nano-dot placement on the substrate, single or multiple carbon nanotubes with controlled site density can be achieved. For example, the direct growth of a single carbon nanotube on the probe tip of scanning tunneling microscope (STM), atomic force microscope (AFM), etc. may be achieved. Well-defined spacing of multiple carbon nanotubes with multi-electron beam lithography can improve the patterning ability by  $10^4 - 10^6$  times.

Although the invention has been described in detail for the purpose of illustration, it is understood that such detail is solely for that purpose, and variations can be made therein by those skilled in the art without departing from the spirit and scope of the invention which is defined by the following claims.

## WHAT IS CLAIMED:

1. A product comprising a plurality of substantially aligned carbon nanotubes attached to a substrate at a density greater than  $10^4$  nanotubes per square millimeter of substrate.  
5
2. A product as claimed in claim 1, wherein the carbon nanotubes extend outwardly from and substantially perpendicular to the substrate.
3. A product as claimed in claim 1, wherein the carbon nanotubes extend outwardly from and at a non-perpendicular angle with respect to the substrate.
- 10 4. A product as claimed in claim 1, wherein the carbon nanotubes extend substantially parallel to the substrate.
5. A product as claimed in claim 1, wherein the nanotubes have a diameter between 4 to 500 nanometers.
6. A product as claimed in claim 1, wherein the nanotubes have a diameter of at least  
15 50 nanometers.
7. A product as claimed in claim 1, wherein the substrate has a strain point or melting point temperature up to 3000°C.
8. A product as claimed in claim 1, wherein the substrate has a strain point or melting point temperature of at least about 300°C.
- 20 9. A product as claimed in claim 1, wherein the substrate comprises glass, silica, quartz, silicon, iron, cobalt, nickel, an alloy of iron, cobalt, or nickel, platinum, a ceramic, or a combination thereof.
10. A product as claimed in claim 9, wherein the substrate is a glass plate.
11. A product as claimed in claim 9, wherein the substrate is a silicon wafer.
- 25 12. A product as claimed in claim 1, wherein substantially all carbon nanotubes have a cap distal from the substrate comprising a metal or a metal alloy.

13. A product as claimed in claim 12, wherein the cap is iron, cobalt, nickel, or an alloy of iron, cobalt, or nickel.
14. A product as claimed in claim 13, wherein the cap is nickel.
15. A product as claimed in claim 1, further comprising a filling within the carbon  
5 nanotubes.
16. A product as claimed in claim 1, wherein substantially all carbon nanotubes have an open end.
17. A product as claimed in claim 16, further comprising a filling within the carbon nanotubes.
- 10 18. A product as claimed in claim 17, wherein the filling is hydrogen, lithium ions, bismuth, lead telluride, or bismuth tritelluride.
19. A product as claimed in claim 17, wherein the filling is a pharmacological agent.
20. A product as claimed in claim 17, wherein the filling is enclosed within the carbon nanotubes.
- 15 21. A product comprising a plurality of substantially aligned carbon nanotubes attached to a substrate at a density no greater than  $10^2$  nanotubes per square millimeter of substrate.
22. A product as claimed in claim 21, wherein the carbon nanotubes extend outwardly from and substantially perpendicular to the substrate.
- 20 23. A product as claimed in claim 21, wherein the carbon nanotubes extend outwardly from and at a non-perpendicular angle with respect to the substrate.
24. A product as claimed in claim 21, wherein the carbon nanotubes extend substantially parallel to the substrate.
- 25 25. A product as claimed in claim 21, wherein the nanotubes have a diameter between 4 to 500 nanometers.

26. A product as claimed in claim 21, wherein the nanotubes have a diameter of at least about 50 nanometers.
27. A product as claimed in claim 21, wherein the substrate has a strain point or melting point temperature up to 3000°C.
- 5 28. A product as claimed in claim 21, wherein the substrate has a strain point or melting point temperature of at least about 300°C.
29. A product as claimed in claim 21, wherein the substrate comprises glass, silica, quartz, silicon, iron, cobalt, nickel, an alloy of iron, cobalt, or nickel, platinum, a ceramic, or a combination thereof.
- 10 30. A product as claimed in claim 29, wherein the substrate is a glass plate.
31. A product as claimed in claim 29, wherein the substrate is a silicon wafer.
32. A product as claimed in claim 21, further comprising a filling within the carbon nanotubes.
33. A product as claimed in claim 21, wherein substantially all carbon nanotubes have  
15 an open end.
34. A product as claimed in claim 33, further comprising a filling within the carbon nanotubes.
35. A product as claimed in claim 34, wherein the filling is hydrogen, lithium ions, bismuth, lead telluride, bismuth tritelluride, or a pharmacological agent.
- 20 36. A product as claimed in claim 34, wherein the filling is enclosed within the carbon nanotubes.
37. A product comprising a substrate having a strain point or a melting point temperature between about 300°C and 700°C and one or more carbon nanotubes.
38. A product comprising a substrate having an outer surface and a plurality of  
25 substantially aligned carbon nanotubes originating and extending outwardly from the outer surface.

39. A product comprising a substrate having an outer surface and one or more free-standing carbon nanotubes originating and extending from the outer surface.
40. A method of forming a product with one or more carbon nanotubes on a substrate comprising:
- 5       providing a substrate in a reduced pressure environment containing a carbon source gas and a catalyst gas and
- exposing the substrate to a plasma under conditions effective to cause formation and growth of one or more carbon nanotubes on the substrate.
41. A method according to claim 40, wherein the reduced pressure environment has a  
10       pressure between about 0.1 to about 100 Torr.
42. A method according to claim 41, wherein the reduced pressure environment has a pressure between about 1 to about 20 Torr.
43. A method according to claim 40, wherein the product has a strain point or melting point temperature between 300°C and 3000°C.
- 15   44. A method according to claim 40, wherein the substrate comprises glass, silica, quartz, mesoporous silicon, silicon, iron, cobalt, nickel, an alloy of iron, cobalt, or nickel, platinum, a ceramic, or a combination thereof.
45. A method according to claim 44, wherein the substrate is a glass plate.
46. A method according to claim 44, wherein the substrate is a silicon wafer.
- 20   47. A method according to claim 40, wherein the carbon source gas is a saturated or unsaturated linear, branched, or cyclic carbon and hydrogen compound having up to six carbon atoms.
48. A method according to claim 47, wherein the carbon source gas is acetylene, ethylene, or benzene.
- 25   49. A method according to claim 40, wherein the catalyst gas is ammonia or nitrogen.

50. A method according to claim 40, wherein the volume ratio of carbon source gas to catalyst gas ranges from about 1:2 to about 1:10.
51. A method according to claim 40, wherein the substrate is exposed to the plasma at a temperature below 700°C.
- 5 52. A method according to claim 40, wherein the substrate is exposed to the plasma at a temperature above about 300°C.
53. A method according to claim 40, wherein the substrate is exposed to the plasma at a temperature between 300°C and 3000°C.
54. A method according to claim 40, further comprising:
- 10 disposing a catalyst film onto the substrate by radio frequency magnetron sputtering prior to said providing the substrate in a reduced pressure environment containing a carbon source gas and a catalyst gas.
55. A method according to claim 40, wherein the substrate has a catalyst film disposed thereon.
- 15 56. A method according to claim 55, wherein the film has a thickness of at least about 15 nanometers.
57. A method according to claim 55, wherein the film is nickel, iron, cobalt, or an alloy of nickel, iron, or cobalt.
58. A method according to claim 57, wherein the film is nickel.
- 20 59. A method according to claim 55, further comprising:
- varying the carbon nanotube diameter in direct proportion to the film thickness.
60. A method according to claim 40, further comprising:
- disposing a catalyst nano-dot onto the substrate by electron beam evaporation, thermal evaporation, or magnetron sputtering prior to said providing the substrate in a
- 25 reduced pressure environment containing a carbon source gas and a catalyst gas.

61. A method according to claim 60, wherein each nano-dot forms one carbon nanotube.
62. A method according to claim 40, wherein the substrate has at least one catalyst nano-dot disposed thereon.
- 5 63. A method according to claim 62, wherein each nano-dot forms one carbon nanotube.
64. A method according to claim 62, wherein the at least one nano-dot is nickel, iron, cobalt, or an alloy of nickel, iron, or cobalt.
65. A method according to claim 64, wherein the at least one nano-dot comprises  
10 nickel.
66. A method according to claim 40, further comprising:  
varying the carbon nanotube diameter in inverse proportion to the plasma intensity.
67. A method according to claim 40, further comprising:  
15 varying the carbon nanotube length in direct proportion to the plasma intensity.
68. A method according to claim 40, wherein the one or more carbon nanotubes have a cap, and further comprising:  
removing the cap from the one or more carbon nanotubes to form open-end on the one or more carbon nanotubes.
- 20 69. A method according to claim 68, wherein the cap is removed by  $\text{HNO}_3$  solution etching.
70. A method according to claim 68, wherein the cap is removed by argon ion sputtering.
71. A method according to claim 68, further comprising:

adding a filling into the one or more carbon nanotubes after said removing the cap.

72. A method according to claim 71, further comprising:

enclosing the open-ends of the one or more carbon nanotubes after said adding a  
5 filling to store the filling within the one or more carbon nanotubes.

73. A method according to claim 72, wherein the open-ends of the one or more carbon nanotubes are enclosed by electrochemical deposition or magnetron sputtering of a metal onto the one or more carbon nanotubes.

74. A method according to claim 40, wherein the one or more carbon nanotubes have  
10 a closed end and further comprising:

exposing the one or more carbon nanotubes to oxygen under conditions effective to remove the closed end.

75. A method according to claim 74, further comprising:

adding a filling into the one or more carbon nanotubes.

15 76. A method according to claim 74, further comprising:

enclosing the one or more carbon nanotubes after said adding a filling to store the filling within the one or more carbon nanotubes.

77. A method according to claim 76, wherein the one or more carbon nanotubes are enclosed by electrochemical deposition or magnetron sputtering of a metal onto the one  
20 or more carbon nanotubes.

78. A field emission display comprising:

a baseplate having an electron emitting array positioned thereon and  
a phosphor coated plate spaced apart from the baseplate so that electrons emitted from the array impinge on the phosphor coating, wherein the baseplate comprises a  
25 substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of



substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about  $300^{\circ}\text{C}$  and  $700^{\circ}\text{C}$ ; (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate.

79. An electron emitter comprising:  
an electron generating source and

10 a product having at least one carbon nanotube operably connected to the electron generating source to emit electrons from the at least one carbon nanotube, wherein the product comprises a substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of substrate; (3) one or more carbon nanotubes, wherein the product has a strain point or melting point temperature between about  $300^{\circ}\text{C}$  and  $700^{\circ}\text{C}$ ; (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate.

20

80. A scanning electron microscope comprising:  
a vacuum chamber capable of receiving a specimen;  
an electron source for producing electrons;  
a probe for emitting and directing the electrons toward and scanning the specimen  
25 operably disposed within the vacuum chamber;  
a detector operably positioned within the vacuum chamber for collecting radiation issuing from the specimen as a result of scanning by the probe to produce an output signal; and

a display screen operably connected to the detector to display an image of the area  
30 of the specimen scanned by the probe, wherein the probe comprises a substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a

substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about 300°C and 700°C; (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating  
5 and extending outwardly from an outer surface of the substrate.

81. A battery comprising:

an anode;

a cathode;

10 an insulator disposed between the anode and the cathode; and  
an electrolyte,

wherein at least one of the anode and the cathode comprise a product having a substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of  
15 substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about 300°C and 700°C; (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes  
20 originating and extending outwardly from an outer surface of the substrate.

82. A fuel cell comprising:

a housing;

a gas diffusion anode positioned within the housing to form an anode side;

25 a gas diffusion cathode positioned within the housing to form a cathode side;

an electrolyte impregnated matrix or ion exchange membrane positioned between  
and in electrical contact with the anode and the cathode;

an external circuit electrically and operably connecting the anode to the cathode;

and

30 an enclosed hydrogen storage unit operably connected to the anode side  
comprising a product having a substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater

than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about  $300^{\circ}\text{C}$  and  $700^{\circ}\text{C}$ ; (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate, wherein substantially all carbon nanotubes have at least one diffusion path; and hydrogen gas disposed within the carbon nanotubes.

83. A composite comprising:
- 10 a product comprising a substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about  $300^{\circ}\text{C}$  and  $700^{\circ}\text{C}$ ; (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate and
- 15 a dissimilar material in admixture with the product, wherein the dissimilar material is selected from the group consisting of metal, ceramic, glass, polymer, graphite, and mixtures thereof.

84. A high temperature superconductor comprising:
- 25 a product having a substantially non-electrically conductive substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about  $300^{\circ}\text{C}$  and  $700^{\circ}\text{C}$ ; (4) a plurality of substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate,
- 30

a high-temperature copper oxide superconductor material in admixture with the product, and

at least two spaced apart terminals electrically connected to the admixture of the product and the high-temperature copper oxide superconductor material and engagable  
5 with an electric circuit.

85. An electromagnetic interference (EMI) shield comprising:

a product comprising a substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  $10^4$  nanotubes per square millimeter of  
10 substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about 300°C and 700°C; (4) a plurality of substantially aligned carbon nanotubes  
15 originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate and

a dissimilar material in admixture with the product, wherein the dissimilar material is a polymer, graphite, or a combination thereof, wherein said electromagnetic interference shield is operationally positioned with respect to either an electromagnetic  
20 source or an electronic component.

86. A microelectrode comprising:

a product comprising a substantially non-electrically conductive substrate and either (1) a plurality of substantially aligned carbon nanotubes of a density greater than  
25  $10^4$  nanotubes per square millimeter of substrate; (2) a plurality of substantially aligned carbon nanotubes of a density no greater than  $10^2$  nanotubes per square millimeter of a substrate; (3) one or more carbon nanotubes, wherein the substrate has a strain point or melting point temperature between about 300°C and 700°C; (4) a plurality of  
30 substantially aligned carbon nanotubes originating and extending outwardly from an outer surface of the substrate; or (5) one or more free-standing carbon nanotubes originating and extending outwardly from an outer surface of the substrate and

at least one electrically conductive microfiber operably connected to at least one carbon nanotube of the product, wherein the at least one carbon nanotube is operably and electrically connectable to an electric circuit.

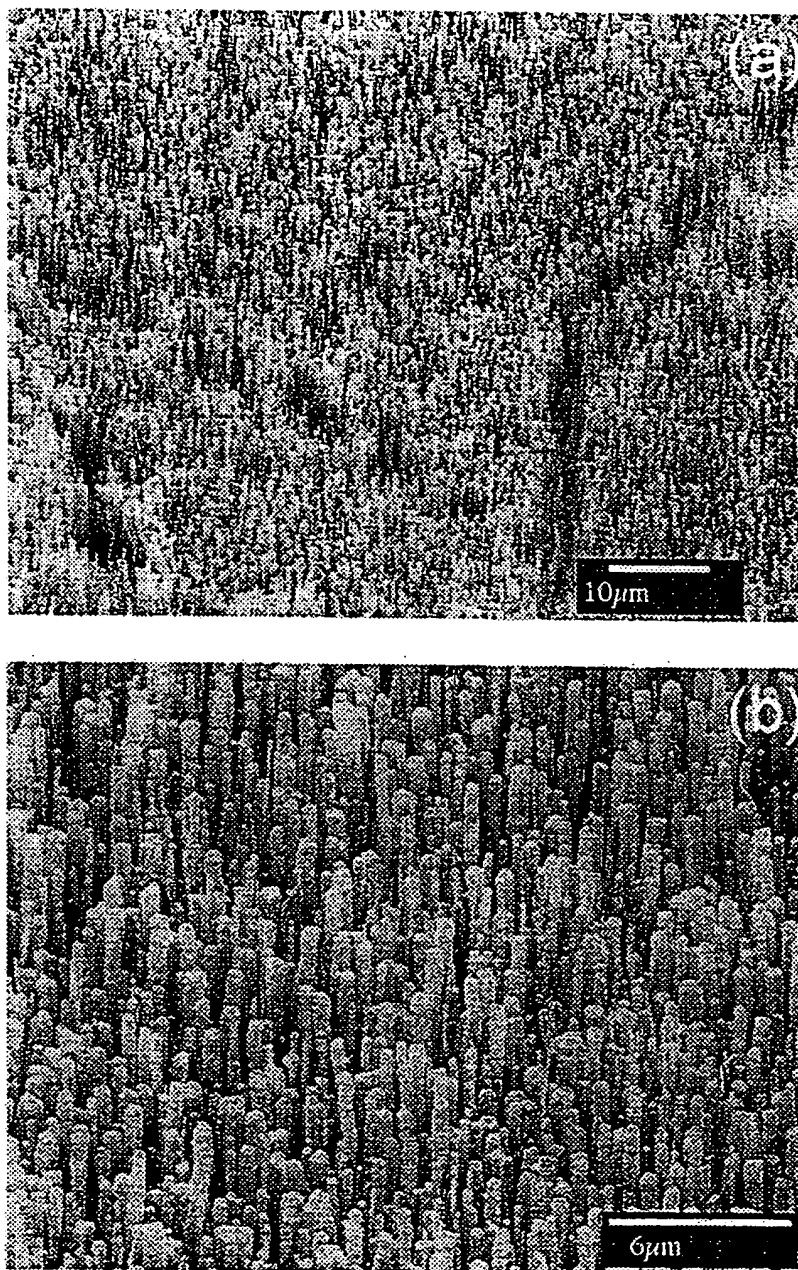
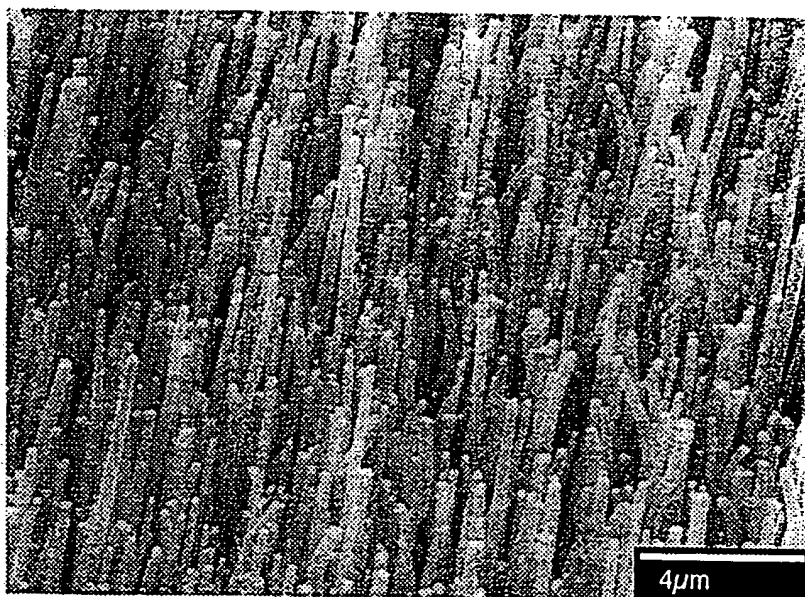
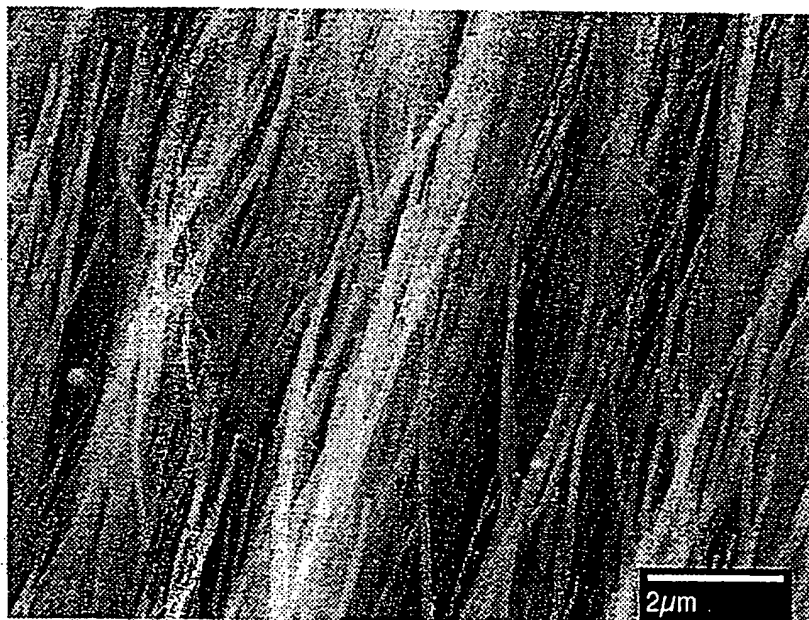


Fig. 1

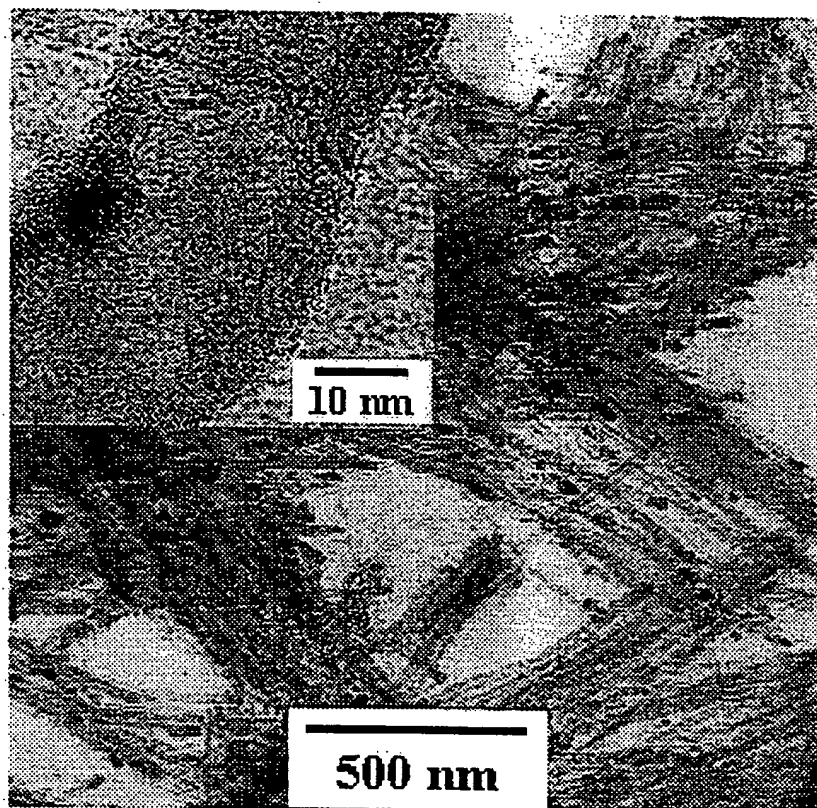


**Fig. 2**



**Fig. 3**

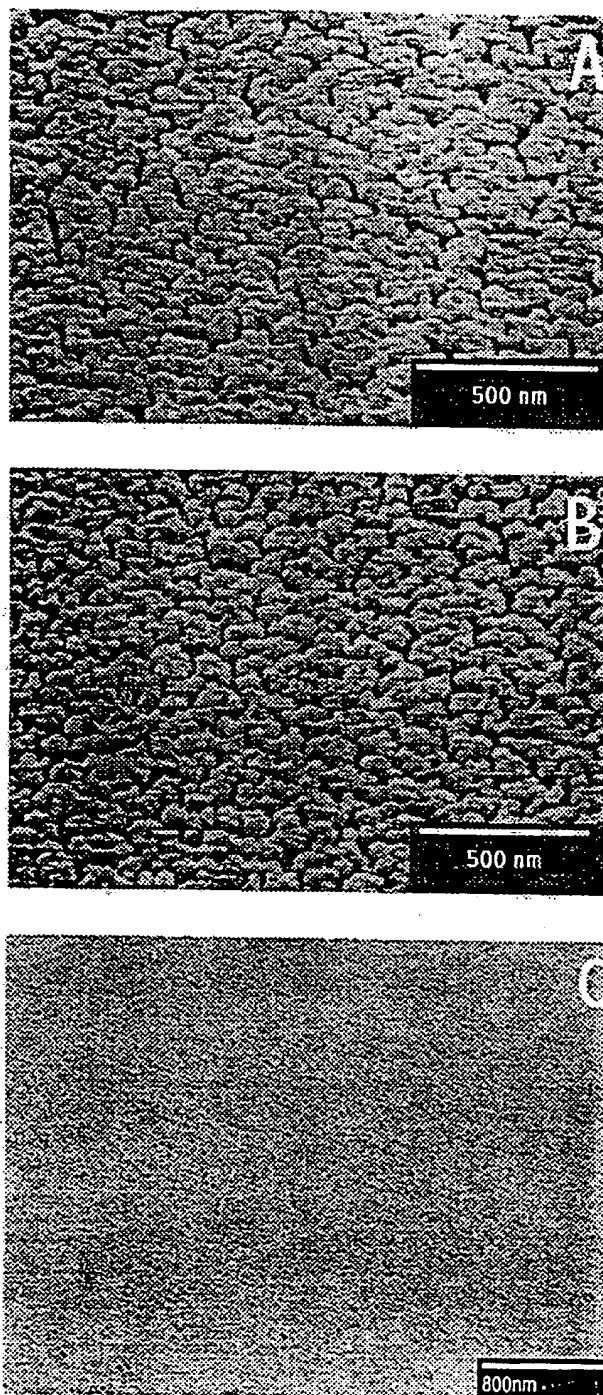




**Fig. 4**



**Fig. 5**



**Fig. 6**

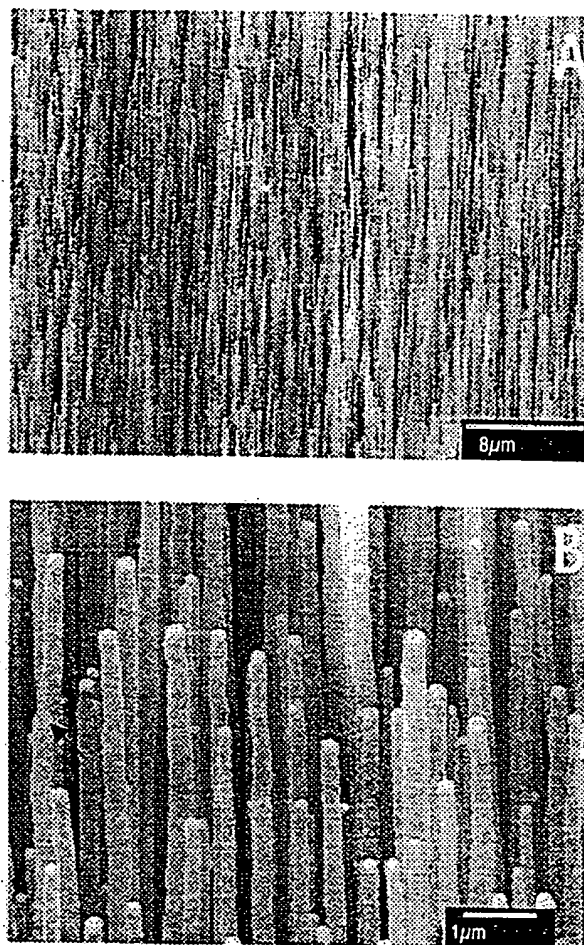
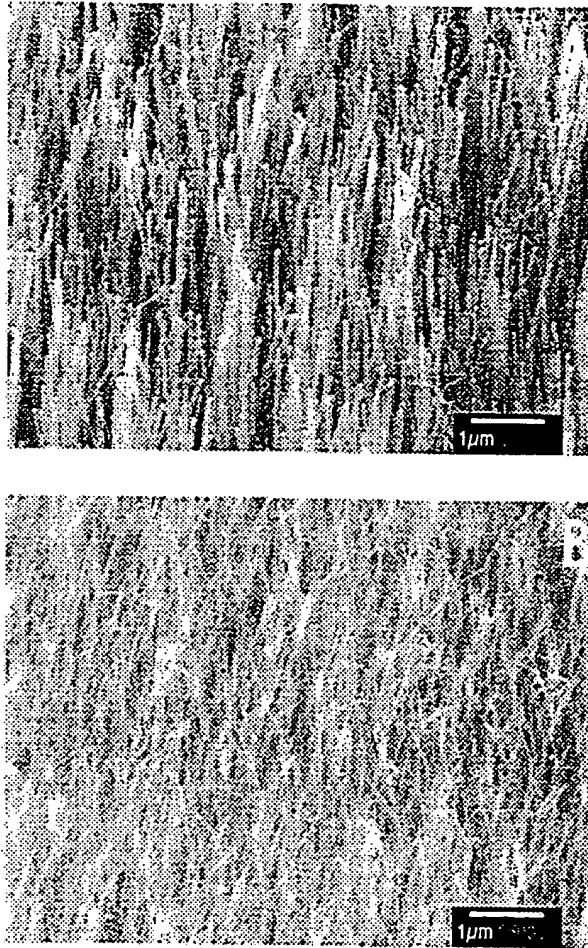


Fig. 7



**Fig. 8**

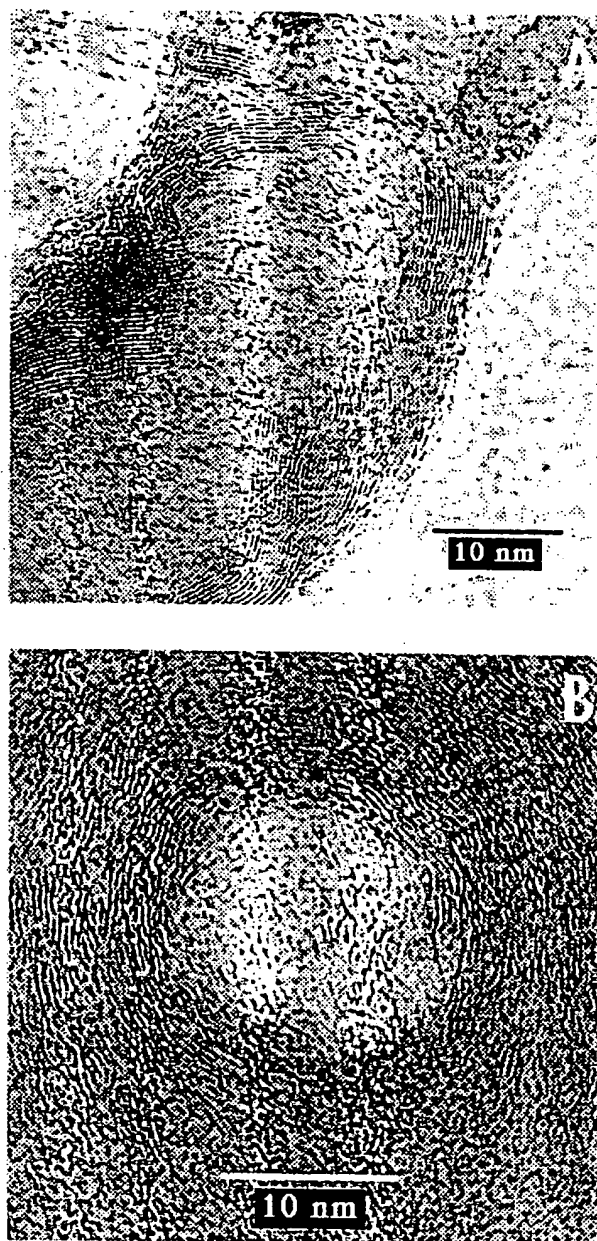


Fig. 9

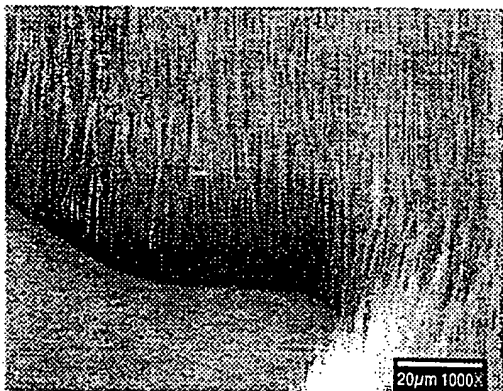


Fig. 10

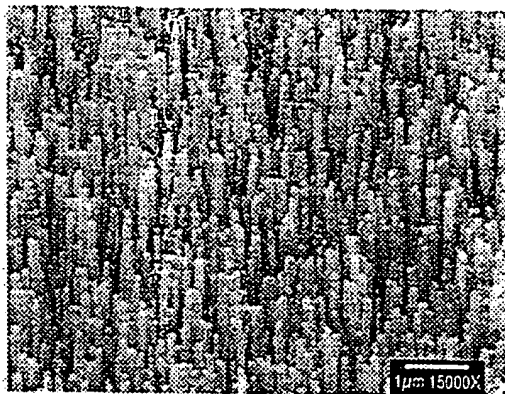


FIG. 11

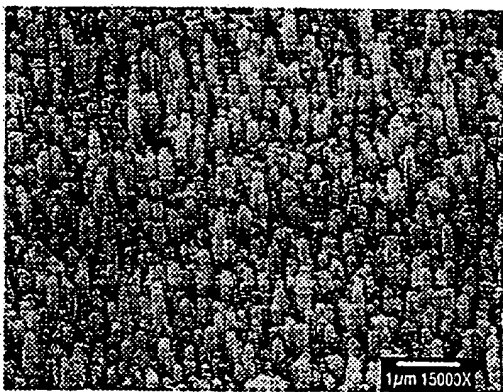


FIG. 12

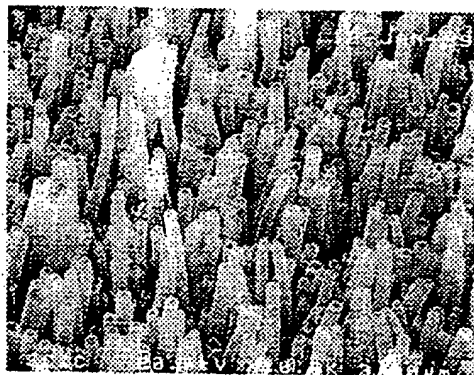


FIG. 13

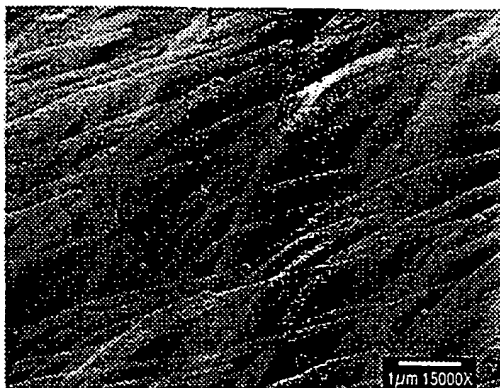


FIG. 14

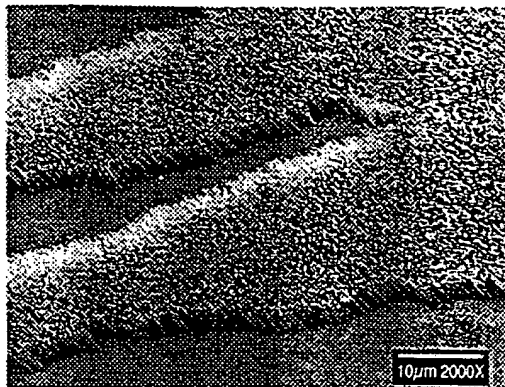


FIG. 15

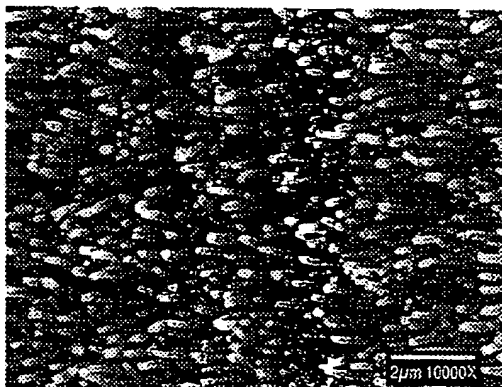


FIG. 16



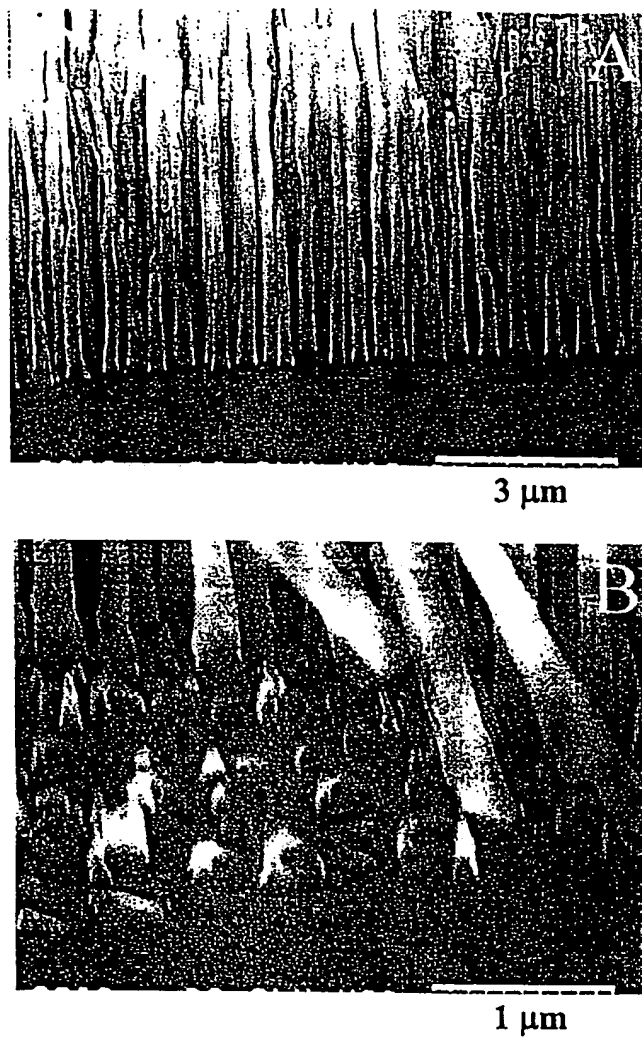


Fig. 17

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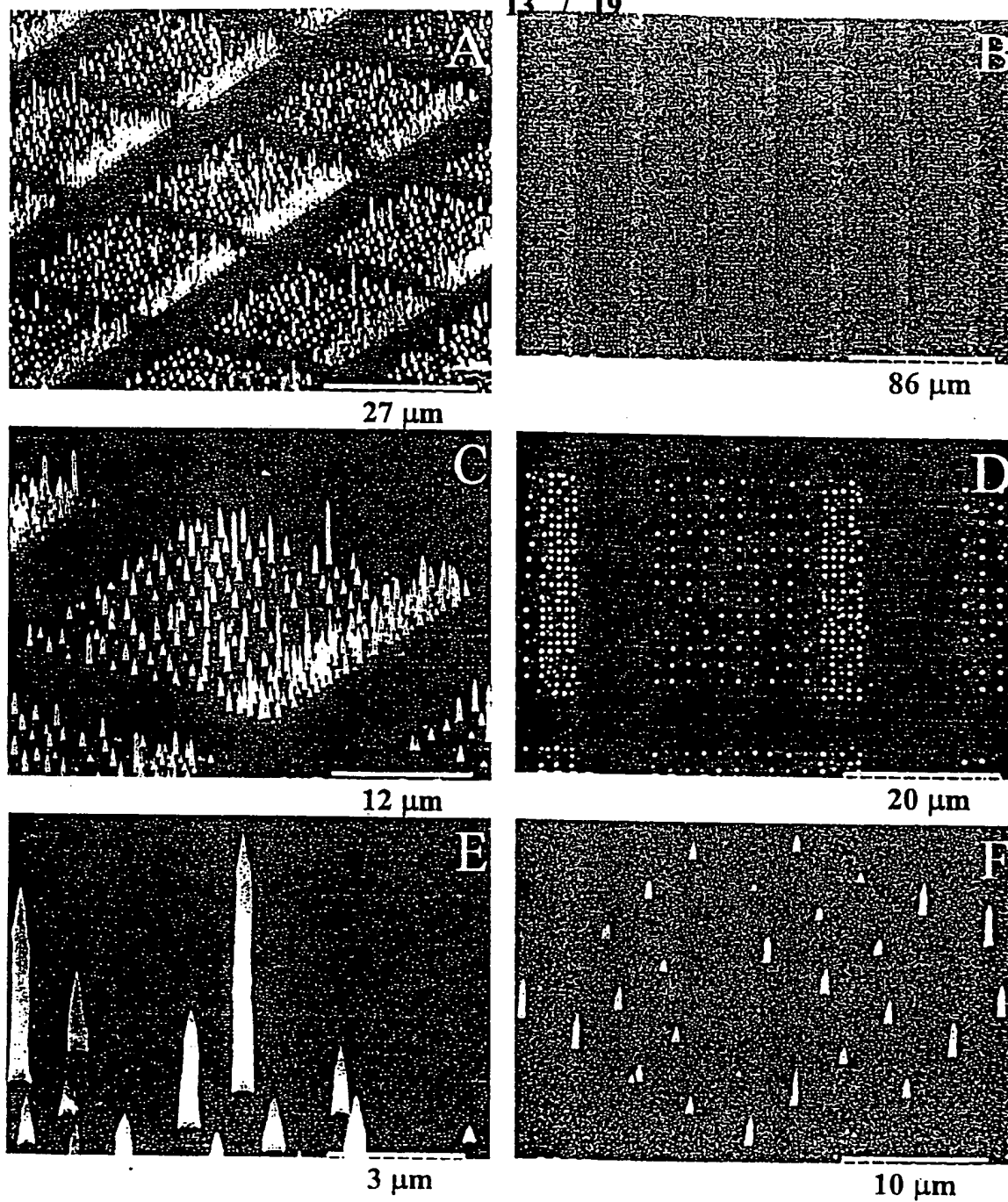


Fig. 18

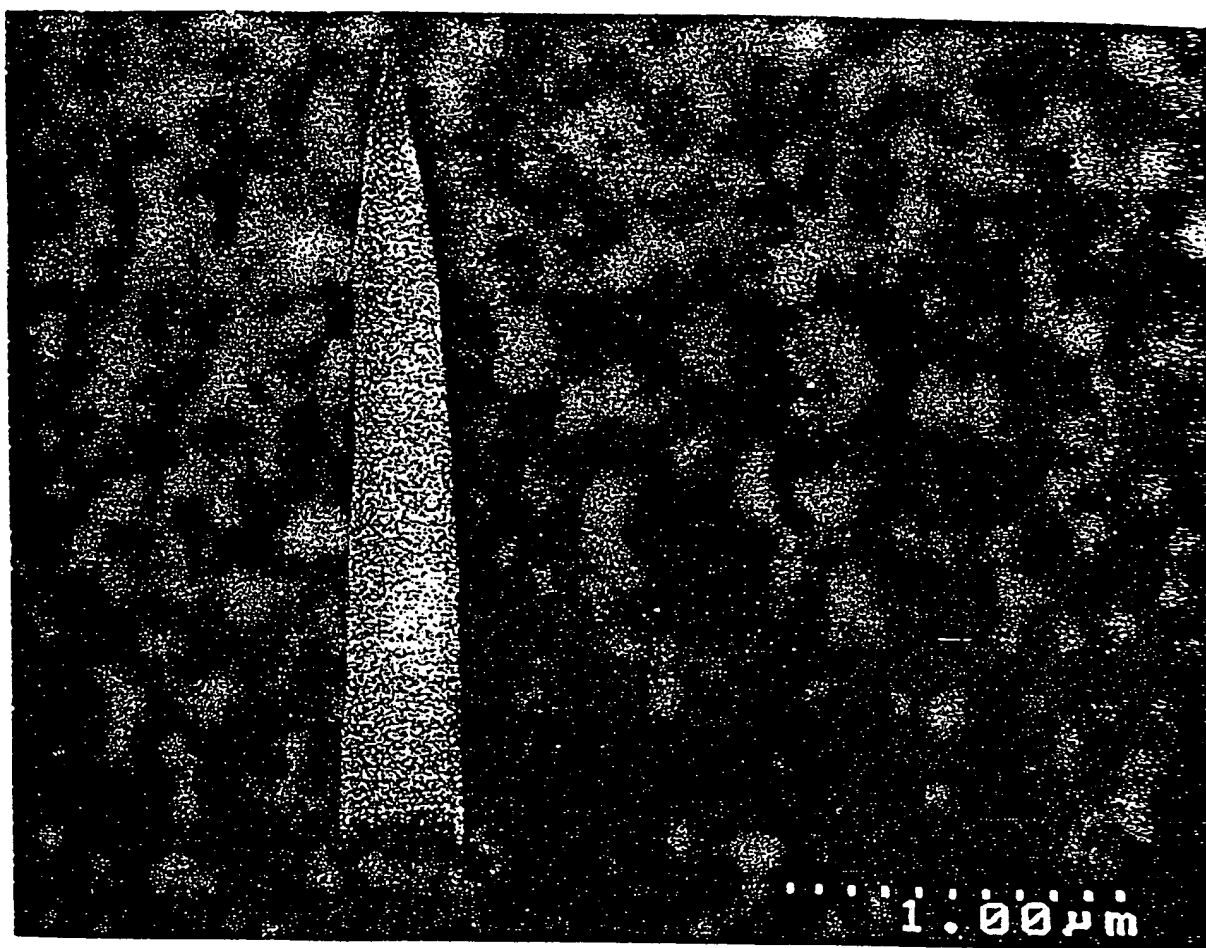


FIG. 19

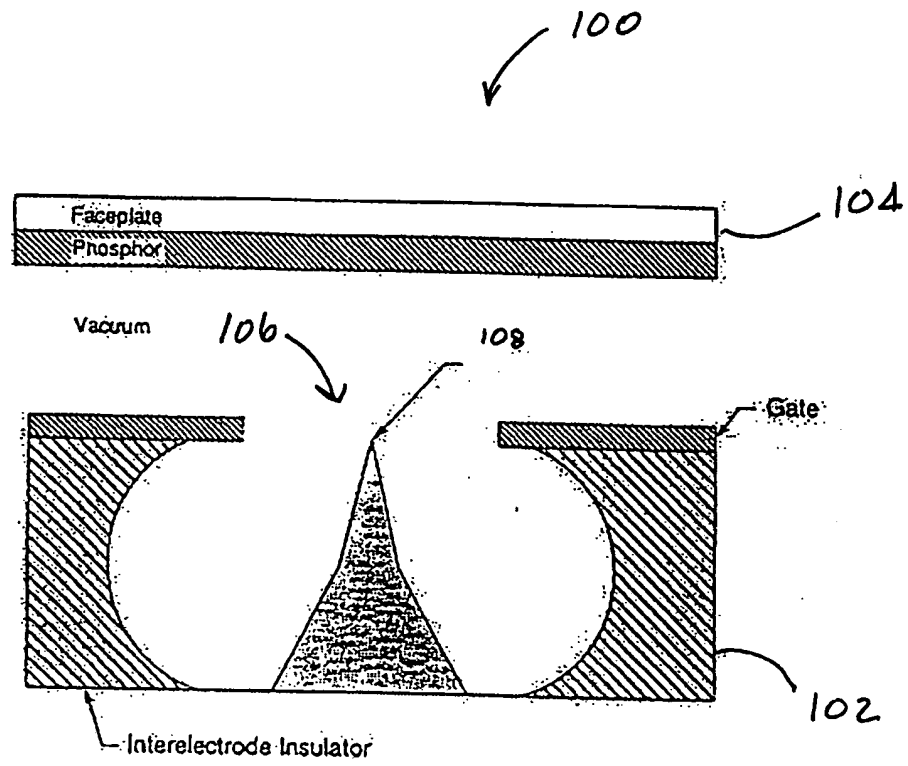


FIG. 20

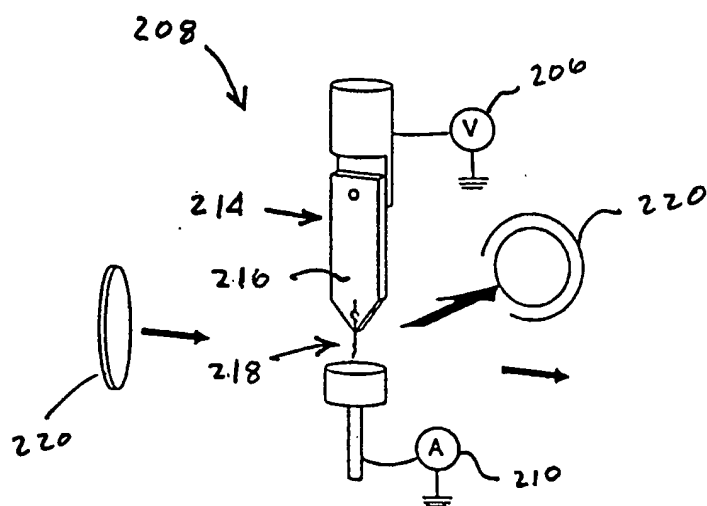


FIG. 21

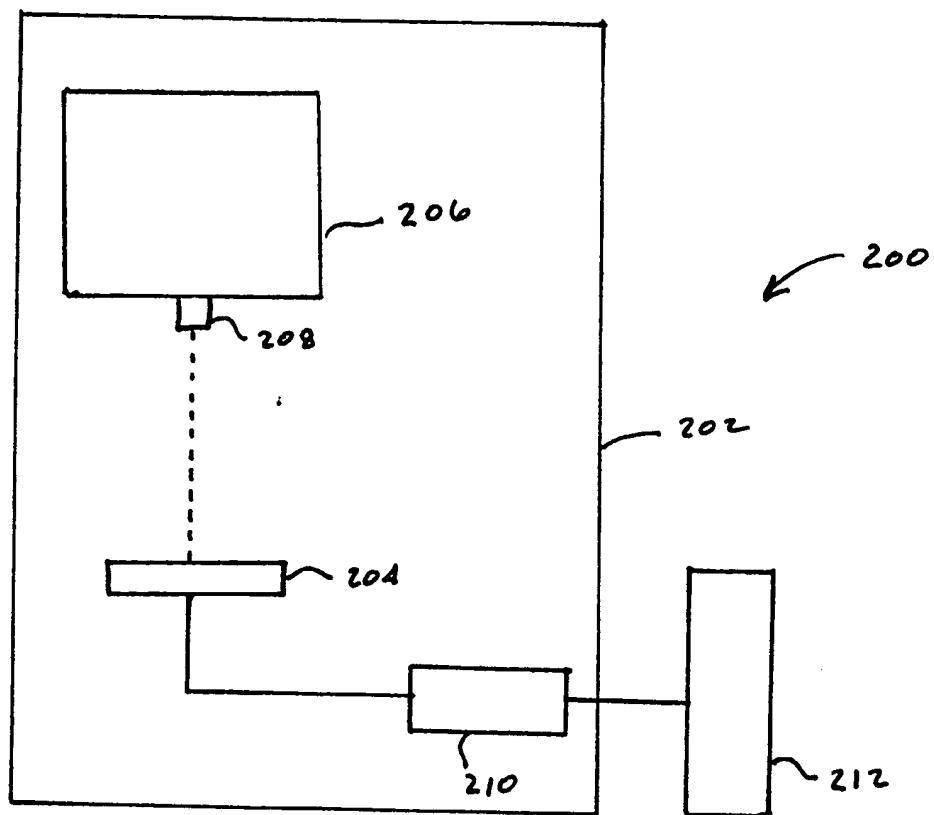


FIG. 22

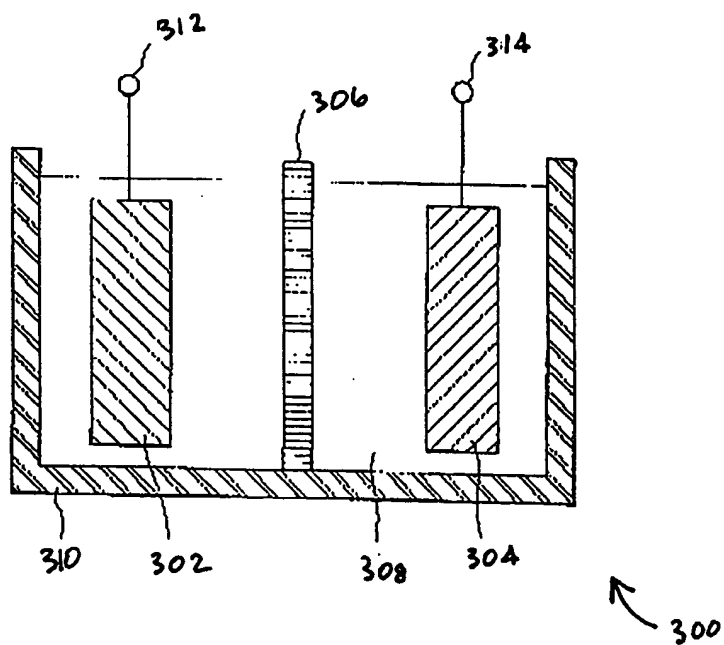


FIG. 23

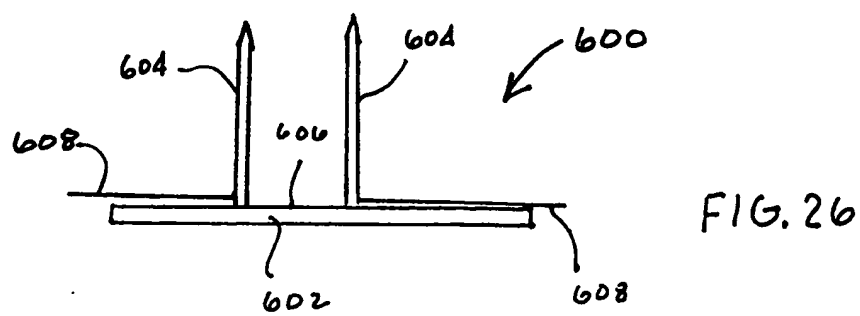


FIG. 26

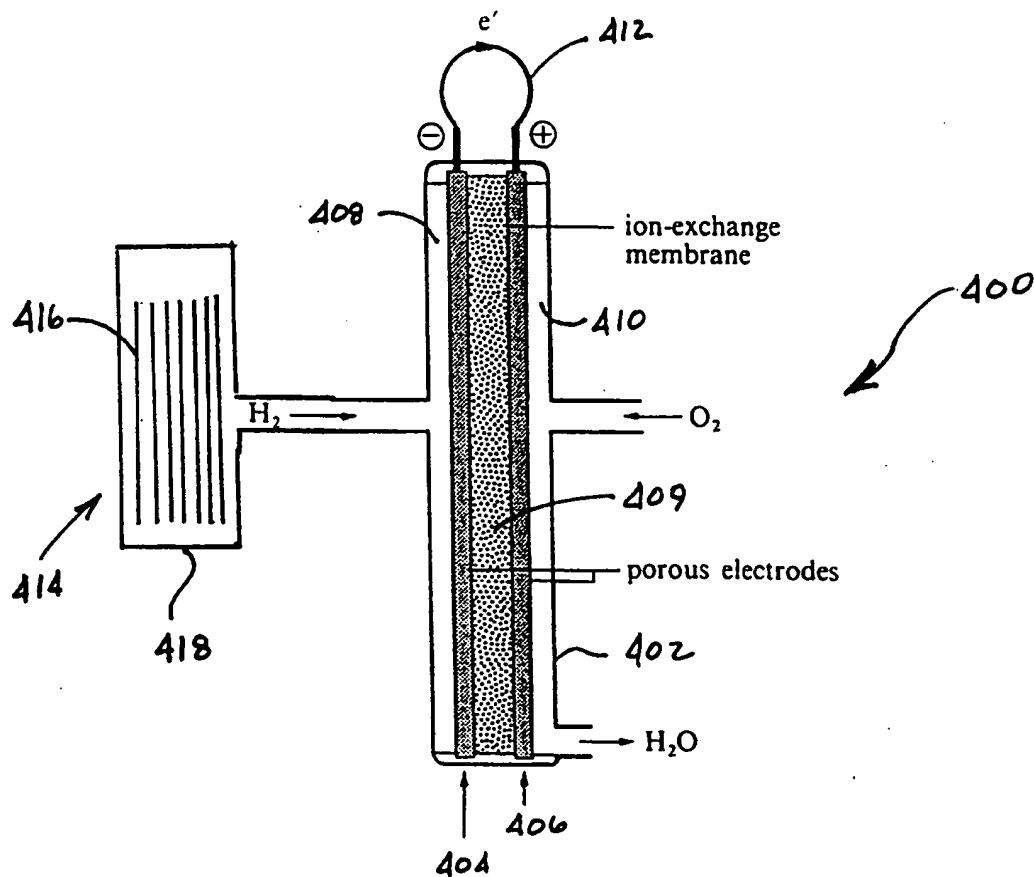


FIG. 24

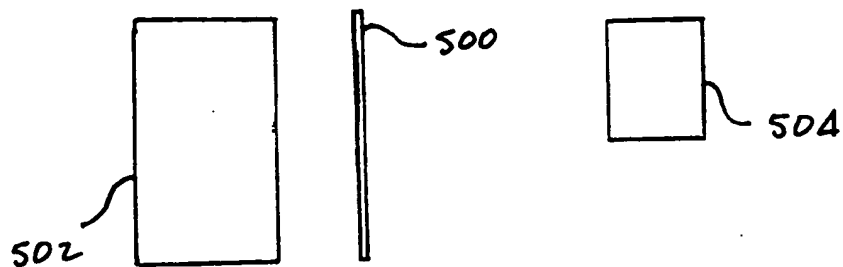


FIG. 25



## INTERNATIONAL SEARCH REPORT

International application No.  
PCT/US99/13648

**A. CLASSIFICATION OF SUBJECT MATTER**

IPC(6) : Please See Extra Sheet.

US CL : Please See Extra Sheet.

According to International Patent Classification (IPC) or to both national classification and IPC

**B. FIELDS SEARCHED**

Minimum documentation searched (classification system followed by classification symbols)

U.S. : 423/445B, 447.1, 447.2, 447.3, 460; 427/216, 249, 562, 580, 590; 164/46; 429/231.8

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

APS, WEST

search terms: carbon nanotube, catalyst film, diameter, melting point

**C. DOCUMENTS CONSIDERED TO BE RELEVANT**

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	US 5,346,683 A (GREEN et al.) 13 September 1994 (13-09-94), col. 2, lines 34-68, col. 3, lines 44-60	1-39
A	US 5,648,056 A (TANAKA) 15 July 1997 (15-07-97), col. 1, lines 58-67, col. 2, lines 1-28, col. 5, lines 13-62	1-30
A,E	US 5,916,642 A (CHANG) 29 June 1999 (29-06-99), col. 1, lines 58-67, col. 2, lines 1-20, col. 4, lines 13-50	6-77
A,P	US 5,780,101 A (NOLAN et al.) 14 July 1998 (14-07-98), col. 4, lines 20-67, col. 5, lines 1-27, col. 9, lines 1-47	40-77



Further documents are listed in the continuation of Box C.



See patent family annex.

* Special categories of cited documents:	*T* later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
*A* document defining the general state of the art which is not considered to be of particular relevance	*X* document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
*E* earlier document published on or after the international filing date	*Y* document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art
*L* document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)	*A* document member of the same patent family
*O* document referring to an oral disclosure, use, exhibition or other means	
*P* document published prior to the international filing date but later than the priority date claimed	

Date of the actual completion of the international search

16 AUGUST 1999

Date of mailing of the international search report

21 OCT 1999

Name and mailing address of the ISA/US  
Commissioner of Patents and Trademarks  
Box PCT  
Washington, D.C. 20231

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Authorized officer

Angela J. Martin

Telephone No. (703) 308-0661

## INTERNATIONAL SEARCH REPORT

International application No.  
PCT/US99/13648

## C (Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	US 5,726,524 A (DEBE) 10 March 1998 (10-03-98), col. 2, lines 39-67, col. 2, lines 5-65, col. 7, lines 13-67	1-67
A	JP 407061803 A (NEC CORP) 07 March 1995 (07-03-95), abstract.	1-12
A	WO 009609246 A1 (ISIS INNOVATION) 28 March 1996 (28-03-96), abstract.	12-69
A	WO 009510481 A1 (DU PONT) 20 April 1995 (20-04-95), abstract.	55-65
A,P	JP 410265208 A (FINE CERAMICS CENTER) 06 October 1998 (06-10-98), abstract.	1-39

# INTERNATIONAL SEARCH REPORT

International application No.  
PCT/US99/13648

## Box I Observations where certain claims were found unsearchable (Continuation of item 1 of first sheet)

This international report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:

1. ☐ Claims Nos.:  
because they relate to subject matter not required to be searched by this Authority, namely:
  
2. ☐ Claims Nos.:  
because they relate to parts of the international application that do not comply with the prescribed requirements to such an extent that no meaningful international search can be carried out, specifically:
  
3. ☐ Claims Nos.:  
because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).

## Box II Observations where unity of invention is lacking (Continuation of item 2 of first sheet)

This International Searching Authority found multiple inventions in this international application, as follows:

Please See Extra Sheet.

1. ☒ As all required additional search fees were timely paid by the applicant, this international search report covers all searchable claims.
2. ☐ As all searchable claims could be searched without effort justifying an additional fee, this Authority did not invite payment of any additional fee.
3. ☐ As only some of the required additional search fees were timely paid by the applicant, this international search report covers only those claims for which fees were paid, specifically claims Nos.:
  
4. ☐ No required additional search fees were timely paid by the applicant. Consequently, this international search report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:

Remark on Protest

- ☒ The additional search fees were accompanied by the applicant's protest.
- ☐ No protest accompanied the payment of additional search fees.

# INTERNATIONAL SEARCH REPORT

International application No.

PCT/US99/13648

## A. CLASSIFICATION OF SUBJECT MATTER:

IPC (6):

C01B 31/00, 31/02; D01F 9/12, 9/127; C23C 16/00, 16/26, 16/30; H01J 1/30; H01M 4/02

## A. CLASSIFICATION OF SUBJECT MATTER:

US CL :

423/445B, 447.1, 447.2, 447.3, 460; 427/216, 249, 562, 580, 590; 164/46; 429/231.8

## BOX II. OBSERVATIONS WHERE UNITY OF INVENTION WAS LACKING

This ISA found multiple inventions as follows:

This application contains claims directed to more than one species of the generic invention. These species are deemed to lack Unity of Invention because they are not so linked as to form a single inventive concept under PCT Rule 13.1. In order for more than one species to be searched, the appropriate additional search fees must be paid. The species are as follows:

A. drawn to a first product comprising a substrate having carbon nanotubes at a density of more than  $10^4$  nanotubes/mm<sup>2</sup>.

B. drawn to a second product comprising a substrate having carbon nanotubes at a density of less than  $10^2$  nanotubes/mm<sup>2</sup>.

The claims are deemed to correspond to the species listed above in the following manner:

Specie A: 1-20, 78-86

Specie B: 21-37, 78-86

The following claims are generic: 38, 39, 40-77

The species listed above do not relate to a single inventive concept under PCT Rule 13.1 because, under PCT Rule 13.2, the species lack the same or corresponding special technical features for the following reasons: The first and second products do not share the same structure, greater than  $10^4$  carbon nanotubes/mm<sup>2</sup> for the first product formed at a different plasma intensity from the second product having no more than  $10^2$  nanotube/mm<sup>2</sup>.

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